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Cheiron School 2010

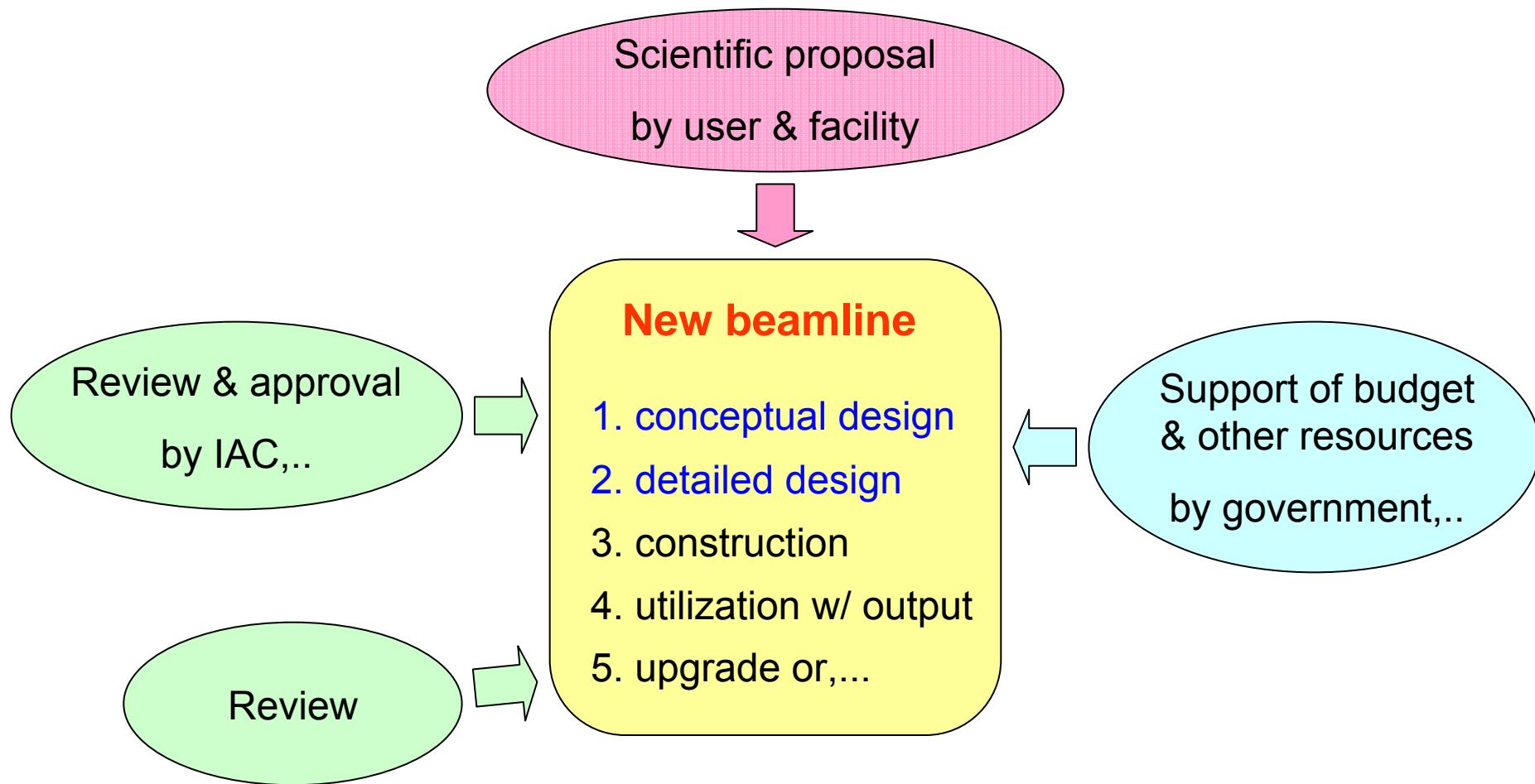
X-ray Beamline Design

Shunji Goto
SPring-8/JASRI

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Process of beamline construction

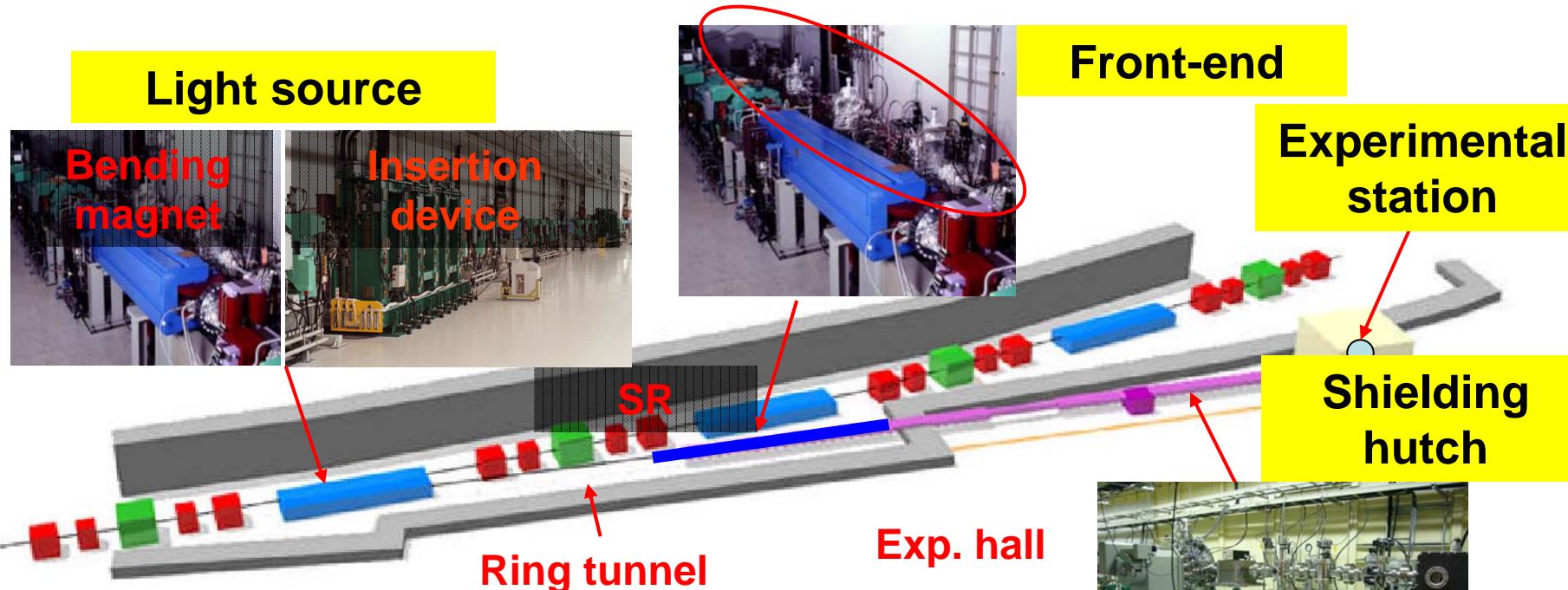


Beamline design is first step and crucial for success of the beamline !

→ Fundamental of X-ray beamline; light source, monochromator, mirror,...

Beamline structure

Beamline = “Bridge” between light source & experimental station



→ Transport and processing of photons

photon energy, energy resolution,
beam size, beam divergence, polarization,..

→ Vacuum

protection of ring vacuum and beamline vacuum

→ Radiation safety

Shielding and interlock

Optics & transport

Monochromator, mirror
shutter, slit
pump,..

Light sources & X-ray optics

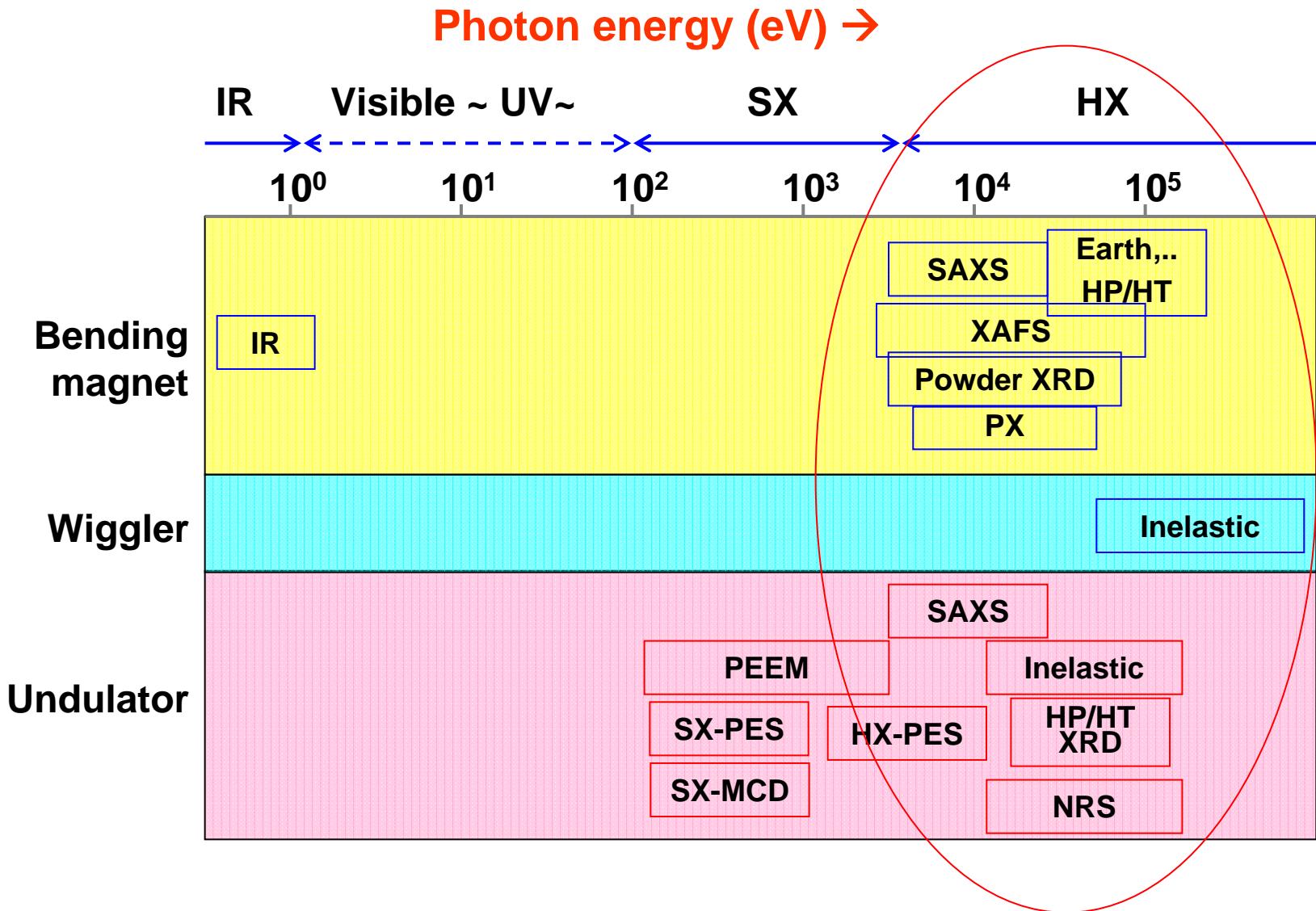
Check points to be considered for your application:

- White or monochromatic
- Energy range
- Energy resolution
- Flux & flux density
- Beam size at sample (micro beam?,...)
- Beam divergence/convergence at sample (Resolution in k-space)
- Higher order elimination w/ mirror
- Polarization conversion
- Spatial coherency

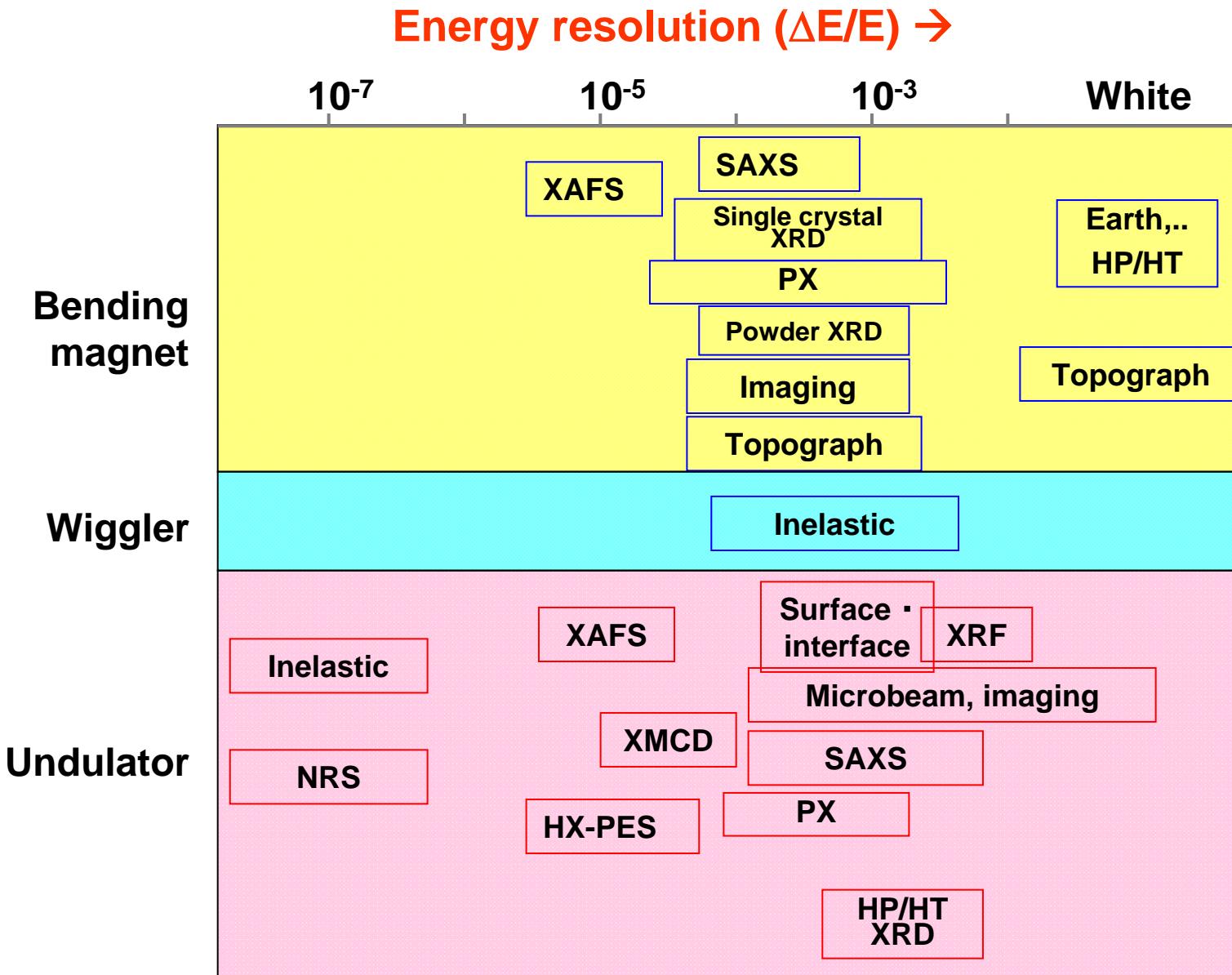
....

→ Light source, monochromator, mirror,
and other optical devices and components

BL classification (energy region)



BL classification (energy resolution)



Light sources

Bending magnet or insertion devices ?

Bending magnet:

for wide energy range, continuous spectrum

for wide beam application for large samples

Undulator (major part of 3GLS beamline):

for high-brilliance beam

for micro-/ nano-focusing beam

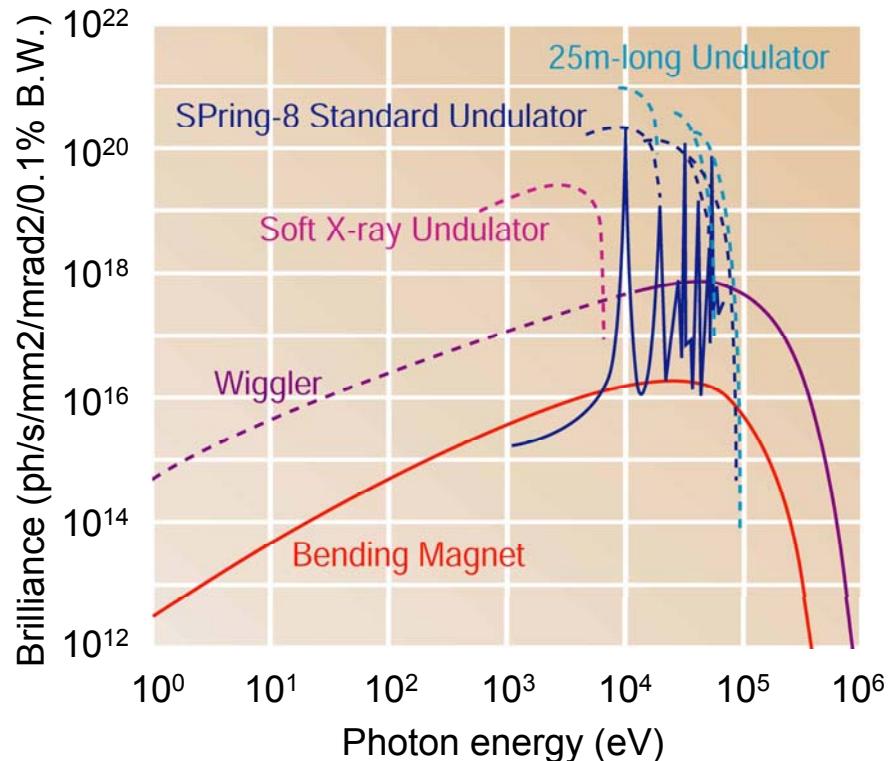
Wiggler:

for higher energy X-rays > 100 keV.

→ *short-period-length undulator*

Power, brilliance, flux density, partial flux,..
can be calculated using code.

e.g. “SPECTRA” by T. Tanaka & H. Kitamura



Brilliance for SPring-8 case

Light sources

Angular divergence and band width

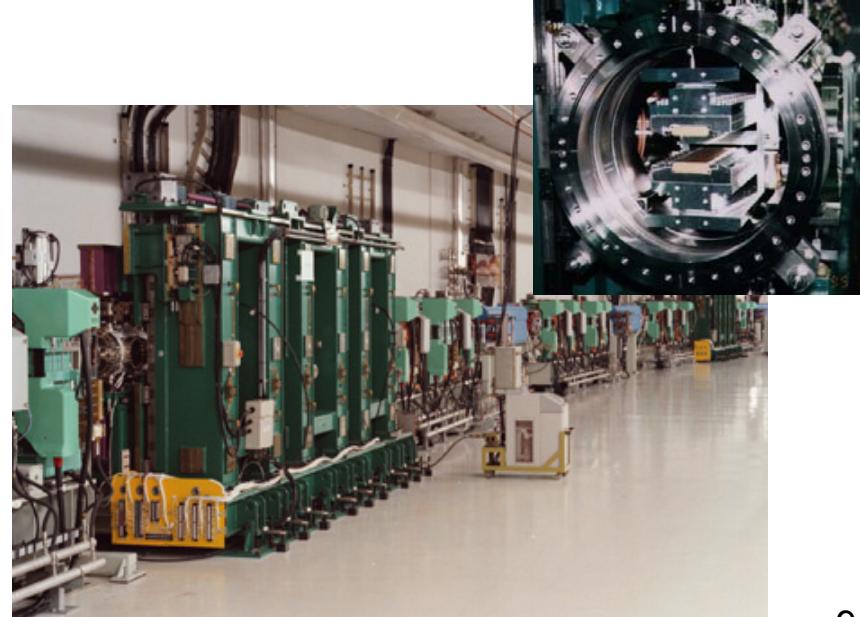
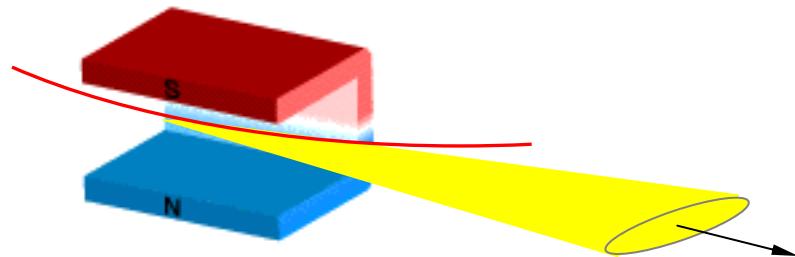
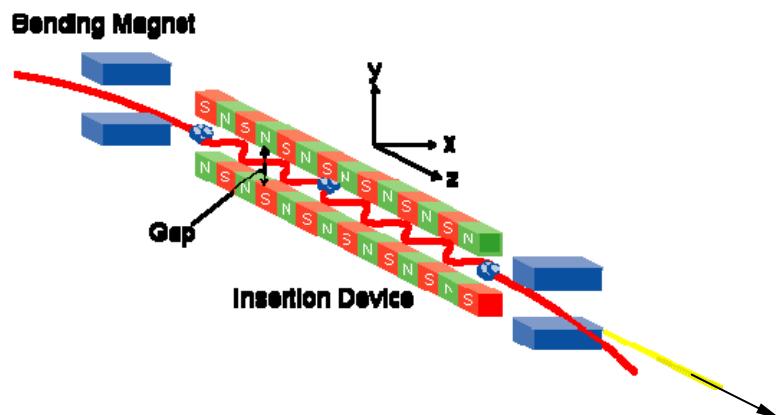
- Bending magnet

$$\sigma_{r'} \approx 0.597 \frac{1}{\gamma} \sqrt{\frac{\lambda}{\lambda_c}}$$

- Undulator

$$\sigma_{r'} \approx \sqrt{\frac{\lambda_n}{2N\lambda_u}} = \frac{1}{2\gamma} \sqrt{\frac{1+K^2/2}{nN}}$$

$$\frac{\Delta E}{E} \approx \frac{1}{nN}$$



Monochromator

Key issues from experimental request:

White or monochromatic ? → **monochromatic**

Energy region ← Bragg's law

Energy resolution ← Source divergence, Darwin width,..

Throughput ← related to energy resolution

Double-crystal monochromator for fixed-exit

Single-bounce monochromator is for limited case

Heat load ← depending on light source

X-ray monochromator using perfect crystal

→ Principle of monochromator

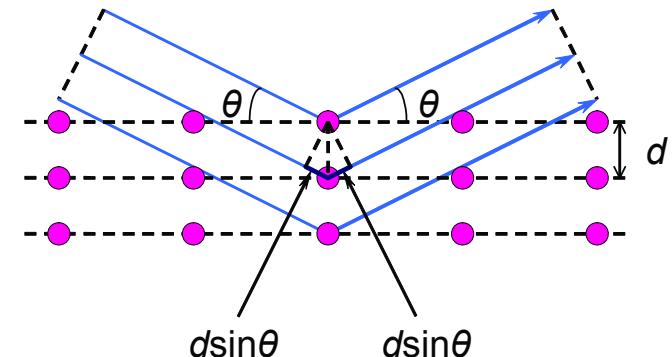
Bragg reflection from perfect single crystal

$$2d \sin \theta_B = n \lambda$$

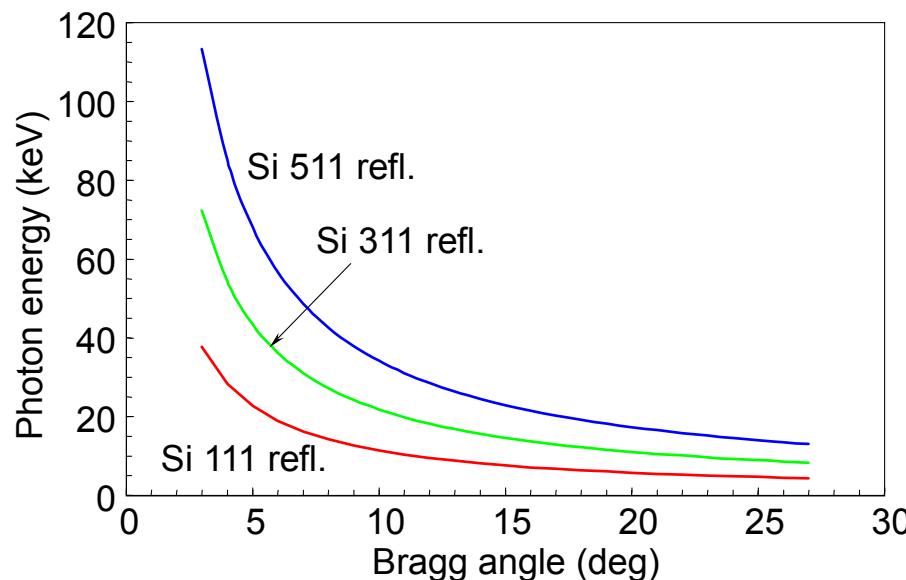
d : Lattice (d)-spacing,

θ_B : glancing angle (Bragg angle),

λ : X-ray wavelength



→ Crystal: silicon, diamond,..



e.g. for SPring-8 standard DCM

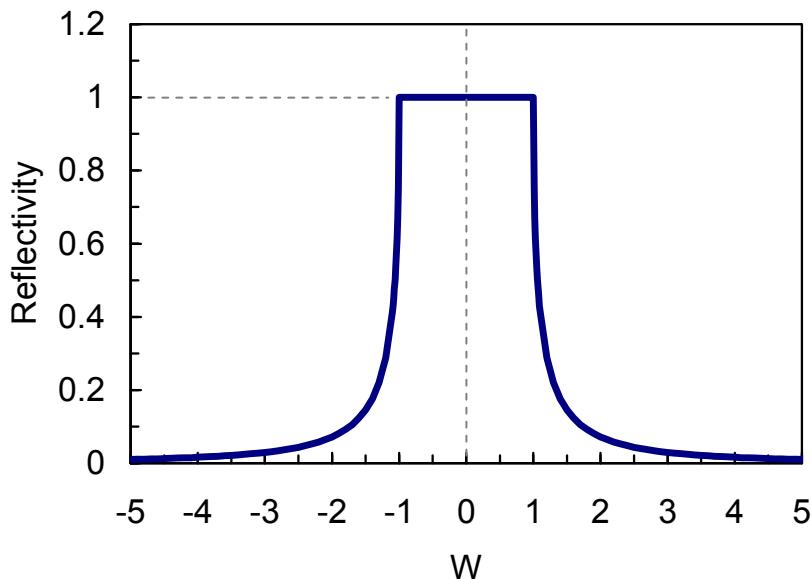
Bragg angle: 3~27°

Photon energy range:
- Crystal & lattice plane
- Bragg angle range

Reflectivity (intrinsic rocking curve)

Darwin curve (intrinsic rocking curve for monochromatic plane wave) for Bragg case, no absorption, and thick crystal:

$$\left\{ \begin{array}{l} R = \frac{|\gamma_h|}{\gamma_0} \left| \frac{E_h}{E_0} \right|^2 = \left(W + \sqrt{W^2 - 1} \right)^2 \quad (W < -1) \\ R = 1 \quad (-1 \leq W \leq 1) \quad \leftarrow \text{Total reflection region} \\ R = \left(W - \sqrt{W^2 - 1} \right)^2 \quad (W > 1) \end{array} \right.$$



For symmetric Bragg case, sigma polarization:

$$W = \left\{ \Delta\theta \sin 2\theta_{BK} + \chi_{0r} \right\} \frac{1}{|\chi_{hr}|}$$

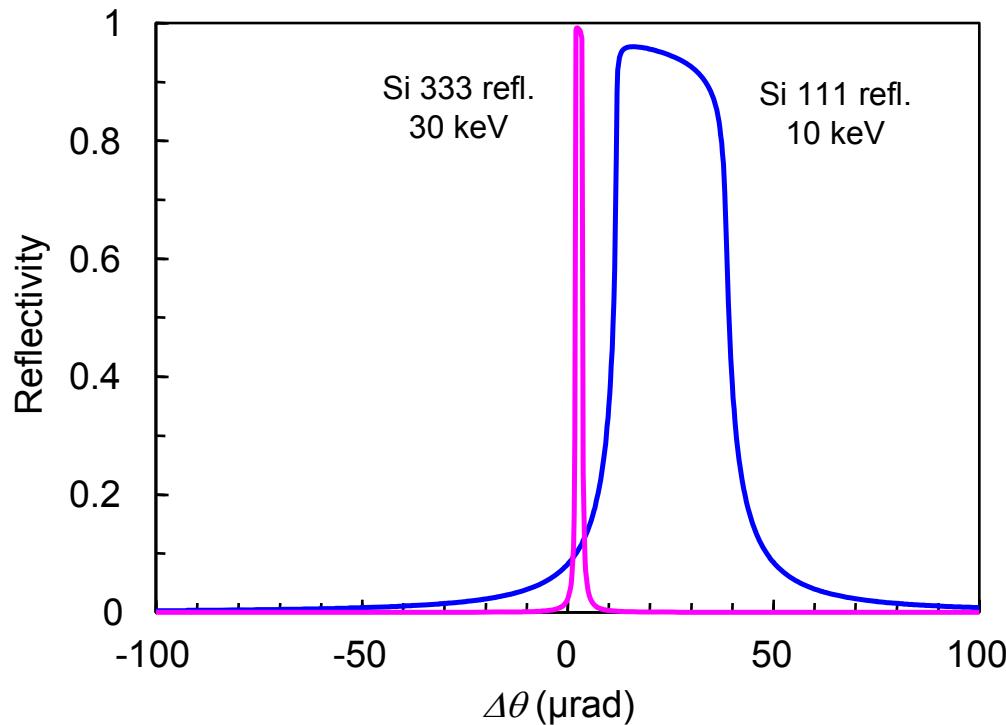
Darwin width → ΔW = 2

$$\omega = \frac{2|\chi_{hr}|}{\sin 2\theta_{BK}} \propto |F_h|$$

Crucial for energy resolution and throughput!

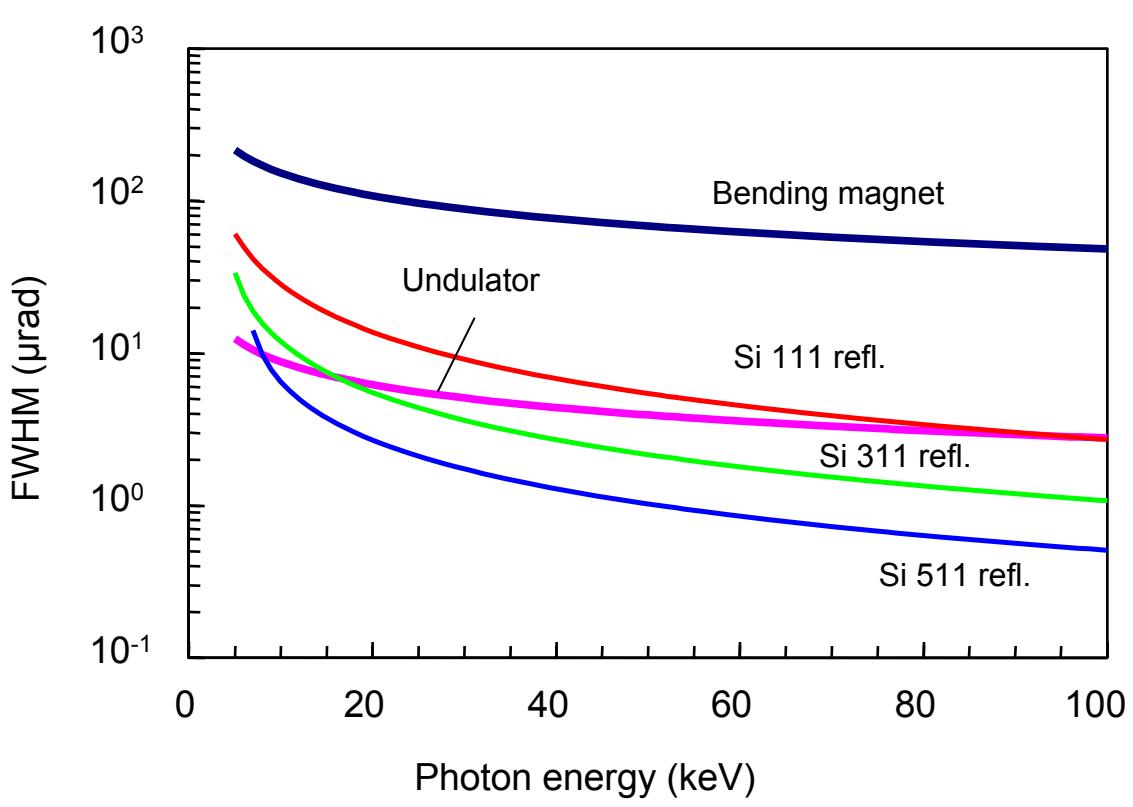
Intrinsic rocking curve for silicon

For Bragg case, **with absorption**, and thick crystal:



- Darwin width of $0.1 \sim 100 \mu\text{rad}$
- Peak ~ 1 with small absorption

Source divergence and diffraction width



Natural divergence

- Bending magnet

$$\sigma_{r'} \approx 0.597 \frac{1}{\gamma} \sqrt{\frac{\lambda}{\lambda_c}} \propto \sqrt{\frac{1}{\hbar\omega}}$$

- Undulator

$$\sigma_{r'} \approx \sqrt{\frac{\lambda}{2N\lambda_u}} \propto \sqrt{\frac{1}{\hbar\omega}}$$

For SPring-8 case:

- Bending magnet

$$\sigma_{r'} \approx 60 \mu\text{rad}$$

- Undulator ($N= 140$)

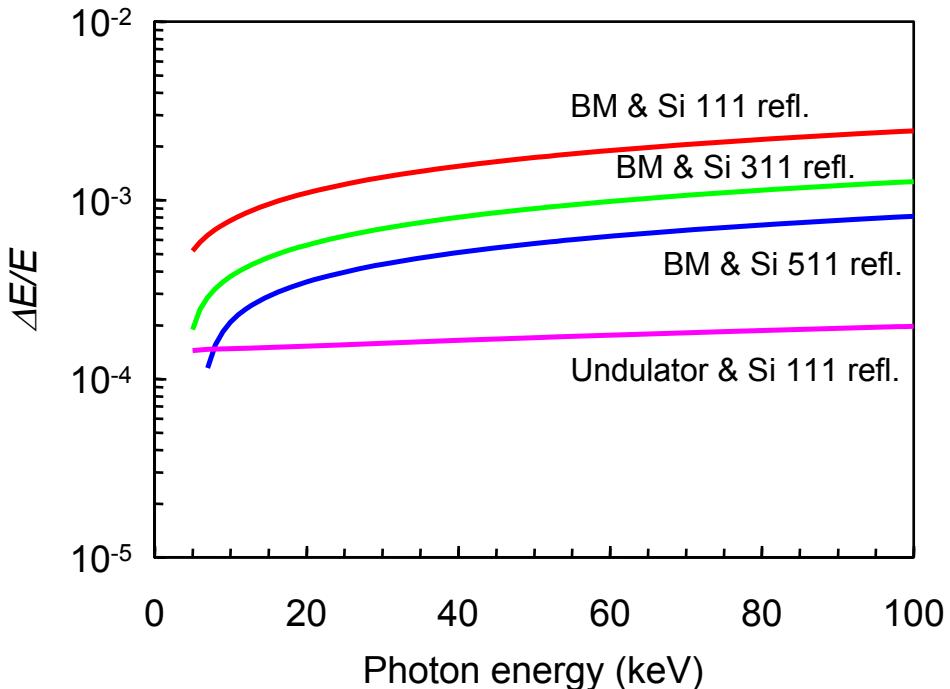
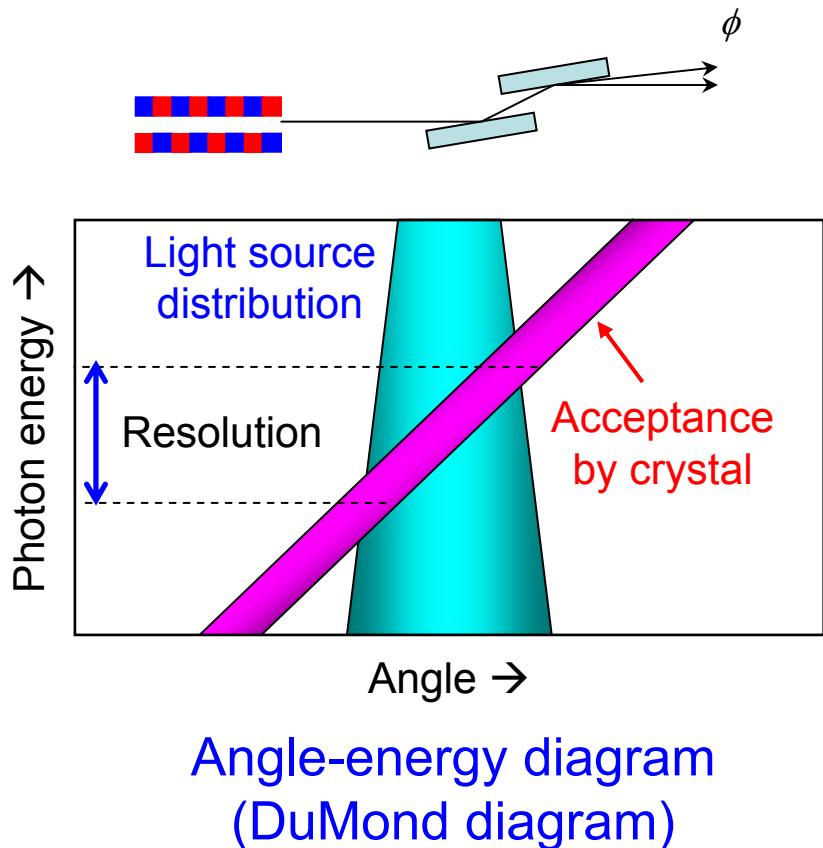
$$\sigma_{r'} \approx 5 \mu\text{rad}$$

Divergence of undulator radiation \sim diffraction width

Energy resolution

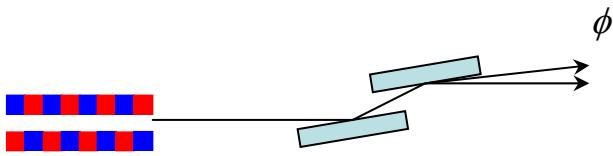
$$\frac{\Delta E}{E} = \cot \theta_B \sqrt{\Omega^2 + \omega^2}$$

Ω : source divergence,
 ω : diffraction width



For usual beamline : $\Delta E/E = 10^{-5} \sim 10^{-3}$

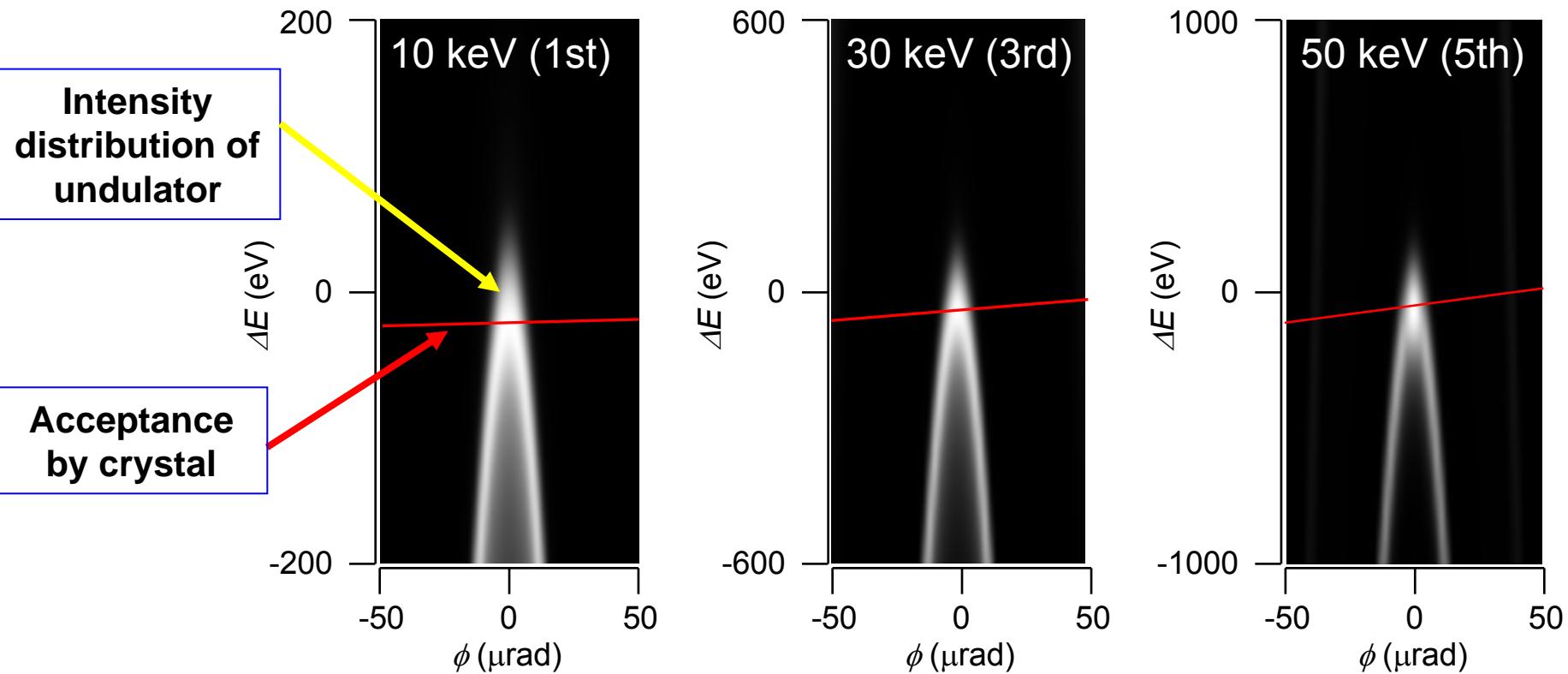
DuMond diagram: undulator ~ DCM



SPring-8 standard undulator

($\lambda_u = 32 \text{ mm}$, $N = 140$, $K = 1.34$, $E_{1\text{st}} = 10 \text{ keV}$)

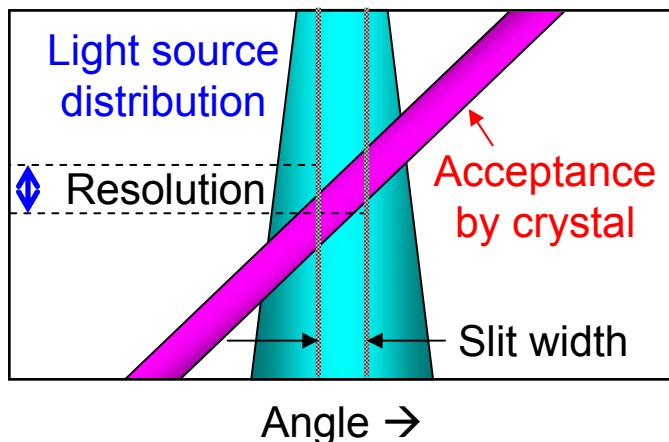
+ DCM (Si 111 refl.)



Wider slit increases unused photons (power) on the monochromator ! 16

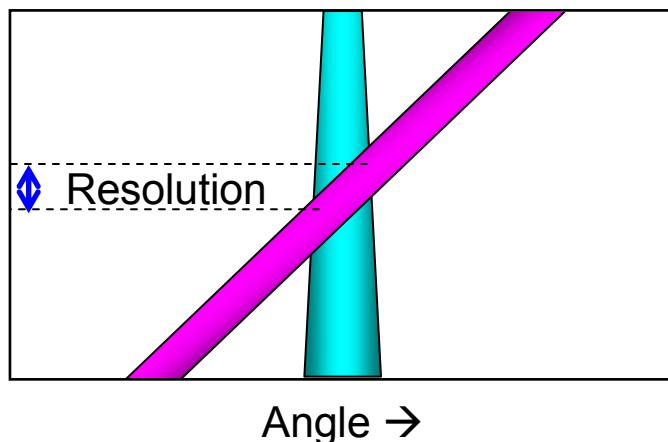
Improvement of energy resolution

Photon energy →



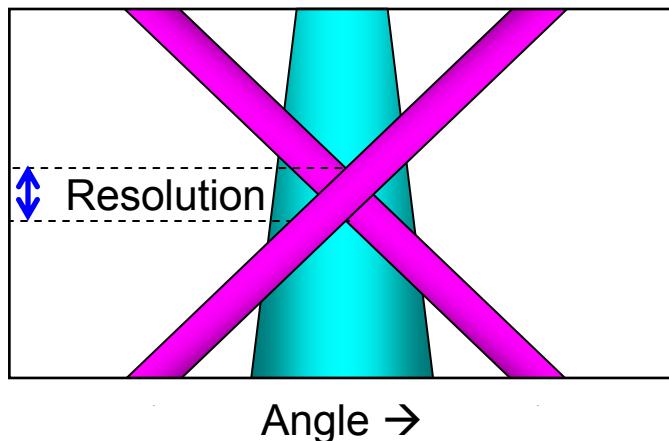
(A) Collimation using slit

Photon energy →



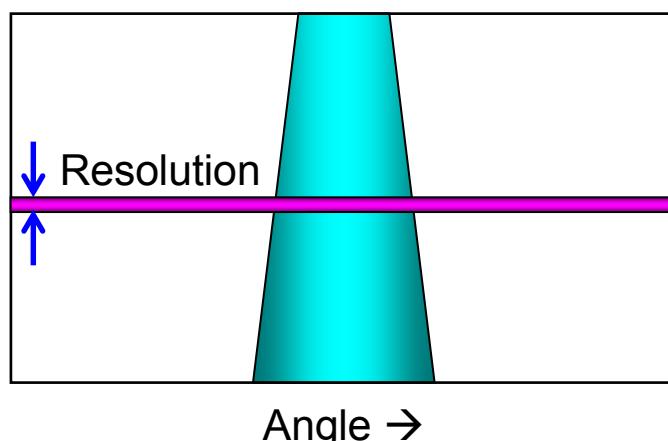
(B) Collimation using pre-optics
w/ collimation mirror, CRL,..

Photon energy →



(C) Additional crystal
w/ $(+,+)$ setting

Photon energy →



(D) HR monochromator of
 $\pi/2$ reflection (~meV)

(B)~(D): restriction on photon energy

Photon flux after monochromator

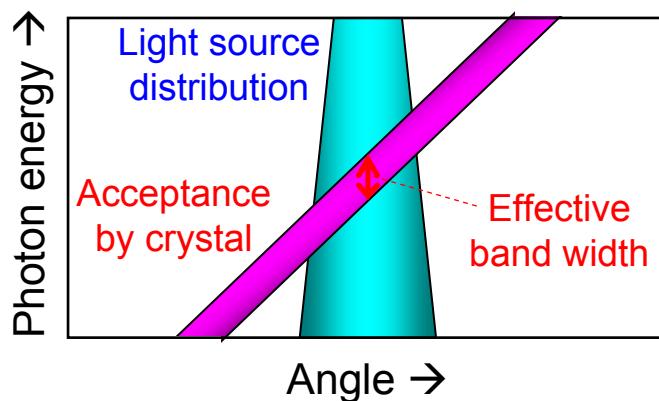
Photon flux (throughput) after monochromator can be estimated using effective band width:

Photon flux (ph/s) =

Photon flux from light source (ph/s/0.1%bw)

x 1000

x Effective band width of monochromator



Throughput is estimated by overlapped area.

Note difference from energy resolution.

Darwin width → energy width

Starting with Darwin width and neglecting anomalous scattering factor f'

$$\chi_{hr} \propto \lambda^2 f_0(d_{hkl})$$

$$\frac{\Delta\lambda}{\lambda} = \omega \cot \theta_B = \frac{2|\chi_{hr}|}{\sin 2\theta_B} \cot \theta_B$$

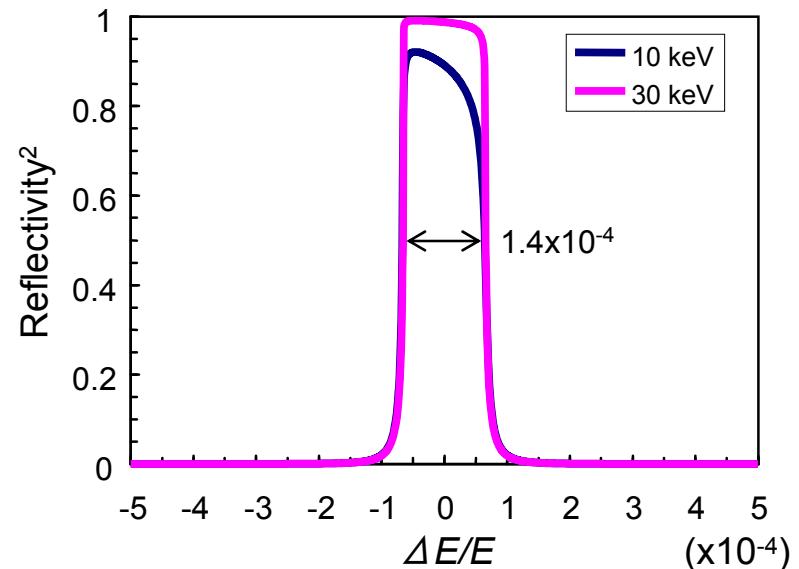
$$\frac{\Delta\lambda}{\lambda} = \frac{|\chi_{hr}|}{\sin^2 \theta_B} = 4d_{hkl}^{-2} \frac{|\chi_{hr}|}{\lambda^2}$$

Energy width:

$$\frac{\Delta E}{E} = -\frac{\Delta\lambda}{\lambda} \propto d_{hkl}^{-2} f_0(d_{hkl})$$



Independent of photon energy



e.g. for Si 111 refl. DCM case

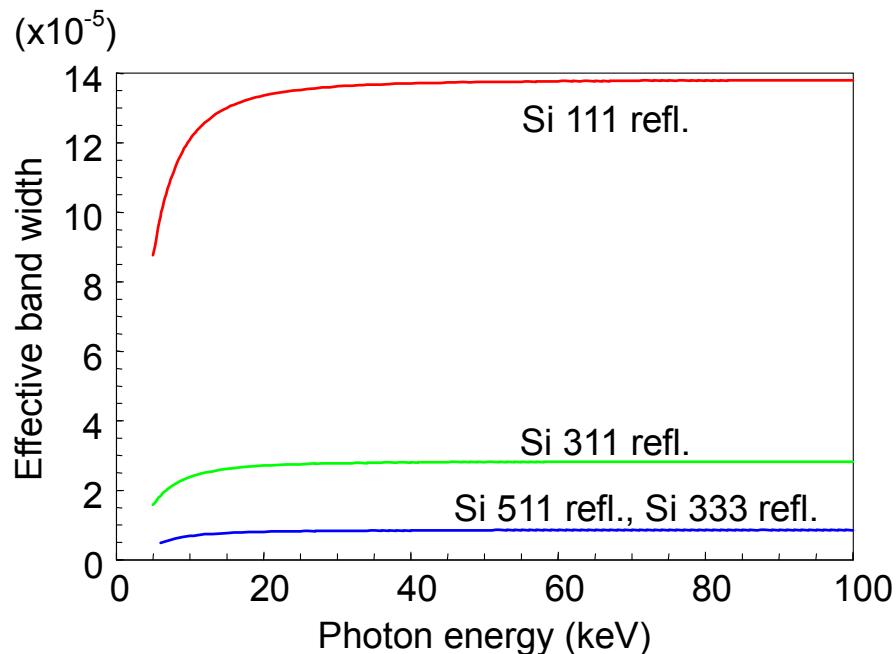
Note relative energy width is constant.

Effective band width (Integrated intensity)

For double-crystal monochromator

$$\left(\frac{\Delta E}{E}\right)_{\text{Eff}} = \frac{|\chi_{hr}|}{2 \sin^2 \theta_{\text{BK}}} \int R(W)^2 dW$$

$\xrightarrow{= \sim 2}$

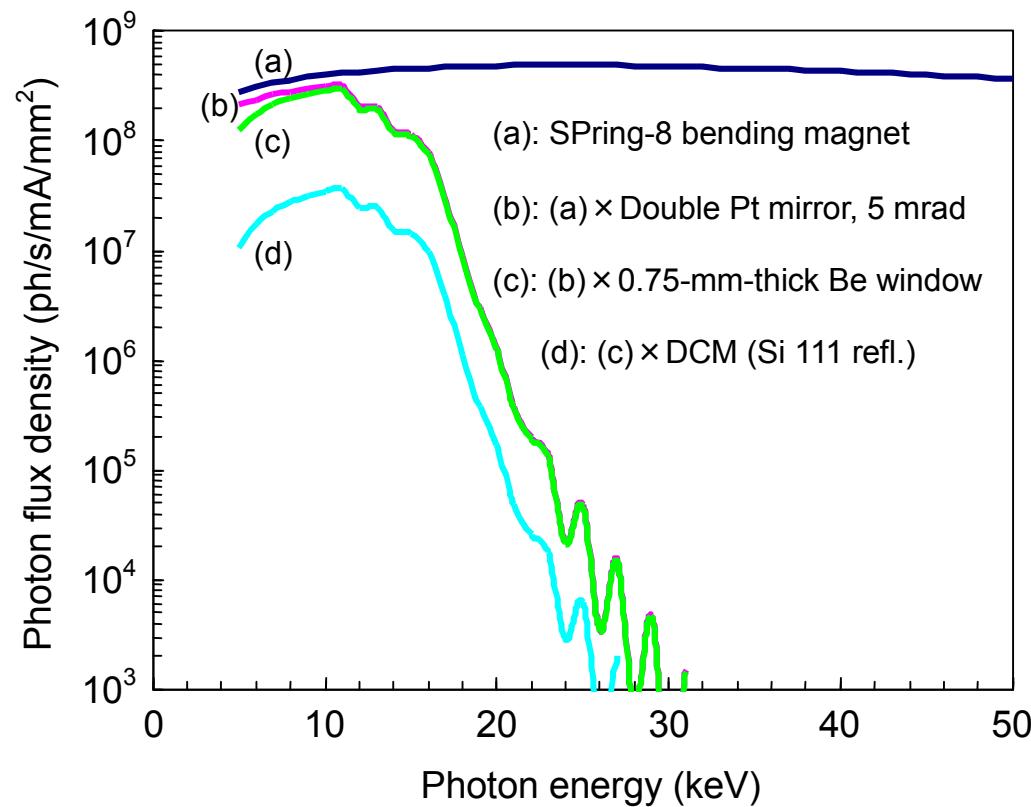


Effective band-width is obtained
by integration of rocking curve.

When you need flux → Lower order (Si 111 refl.,..)

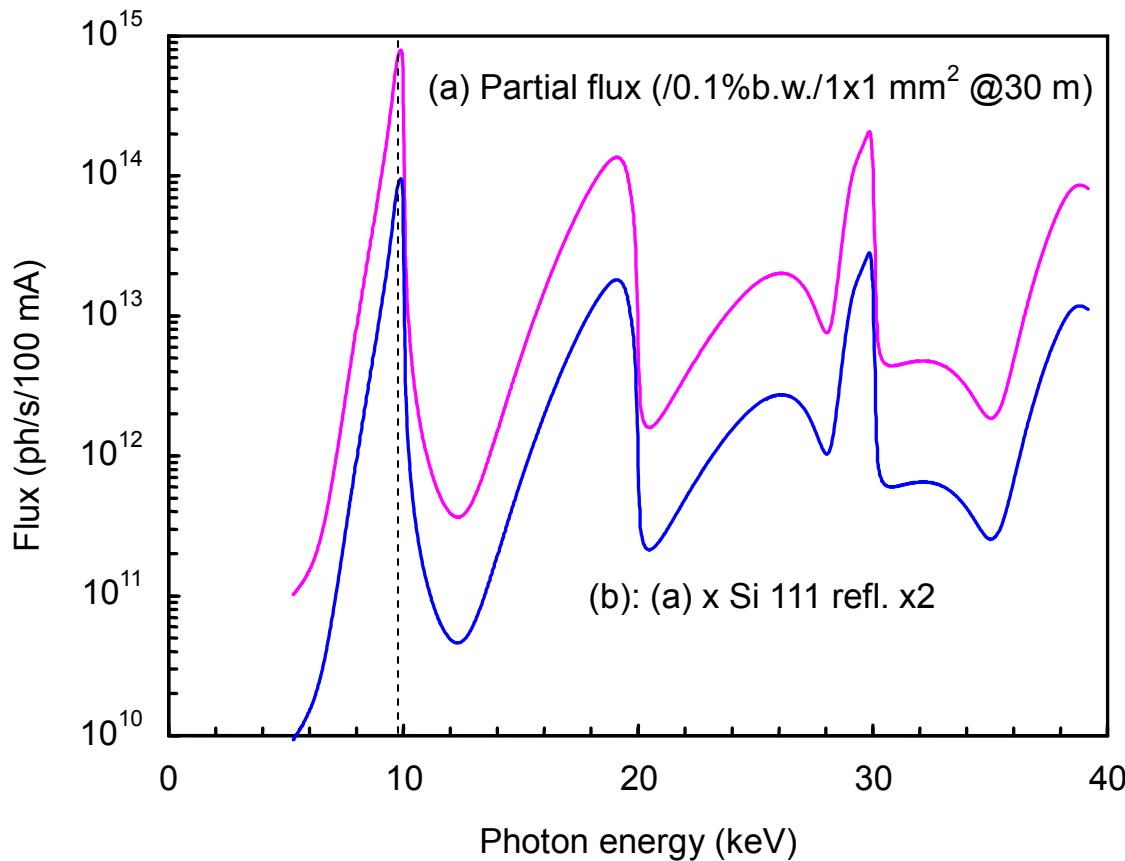
When you need resolution → Higher order (Si 311, Si 511 refl.,..)

Photon flux at bending magnet beamline



Example of photon flux estimation at bending magnet beamline
BL02B1. (Photon flux density at 50 m from the source)

Photon flux at undulator beamline



We can obtain photon flux of $10^{13} \sim 10^{14}$ ph/s/100 mA/mm² using standard undulator sources and Si 111 reflections at SPring-8 beamlines.

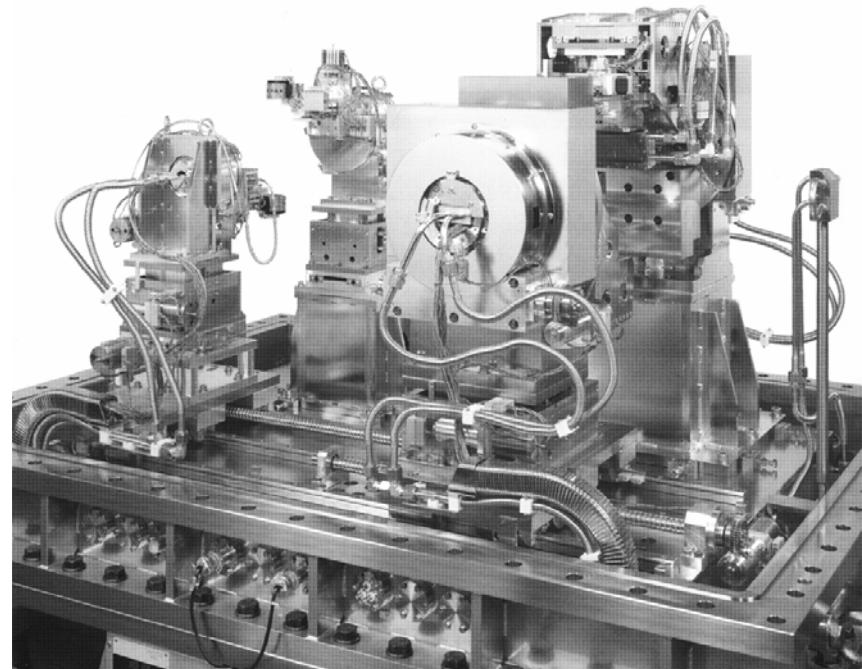
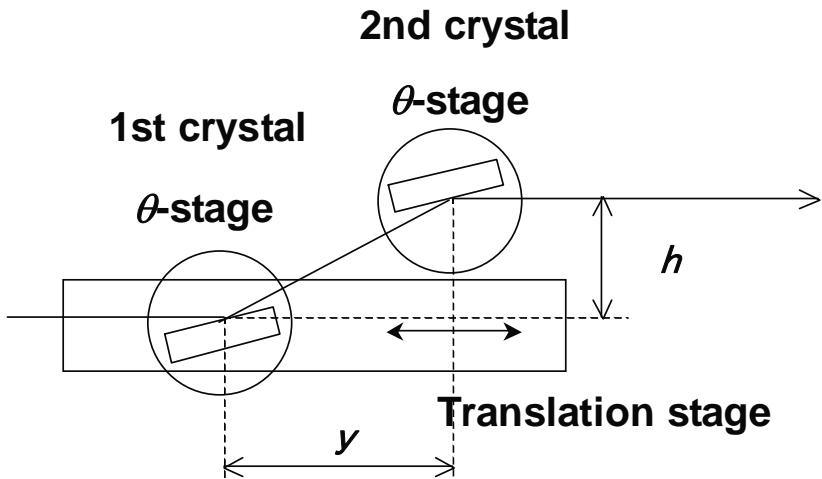
Double-crystal monochromator

Fixed-exit operation for usability at experimental station.

Choose suitable mechanism for energy range
(Bragg angle range).

Precision, stability, rigidity,...

θ_1 + translation + θ_2 computer link



SPring-8 BL15XU

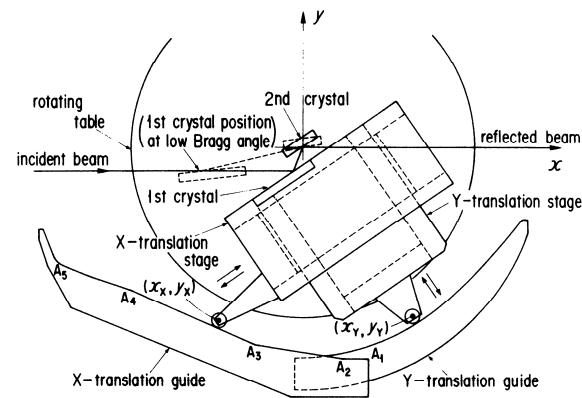
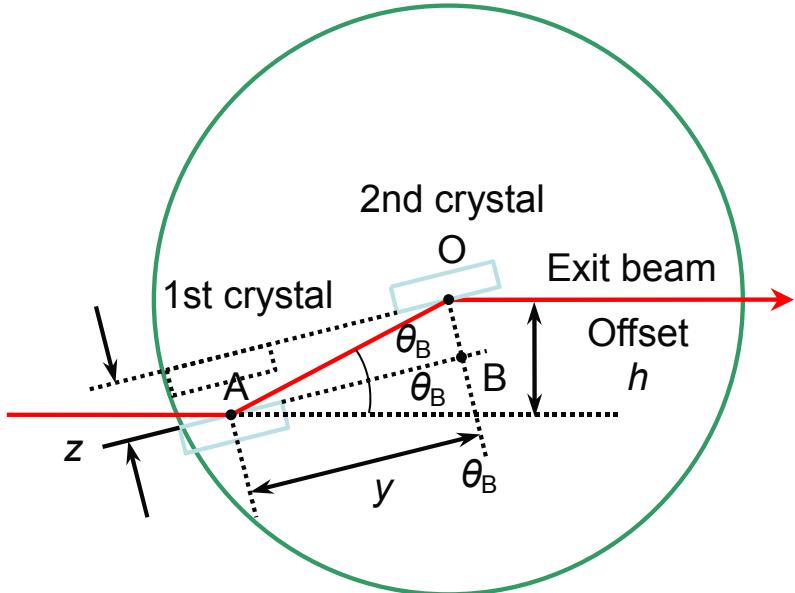
SPring-8 information Vol. 5, No.1 (2000)

$h = 100 \text{ mm}$, $\theta_B = 5.7\text{--}72^\circ$ (for lower energy range)

Large offset, long-stroke translation

Difficulty of adjustment between 1st and 2nd crystal

$\theta +$ two translation (KEK-PF)



PF BL-4C..

Matsushita et al., NIM A246 (1986)



$$h = 25 \text{ mm}, \theta_B = 5^\circ \sim 70^\circ$$

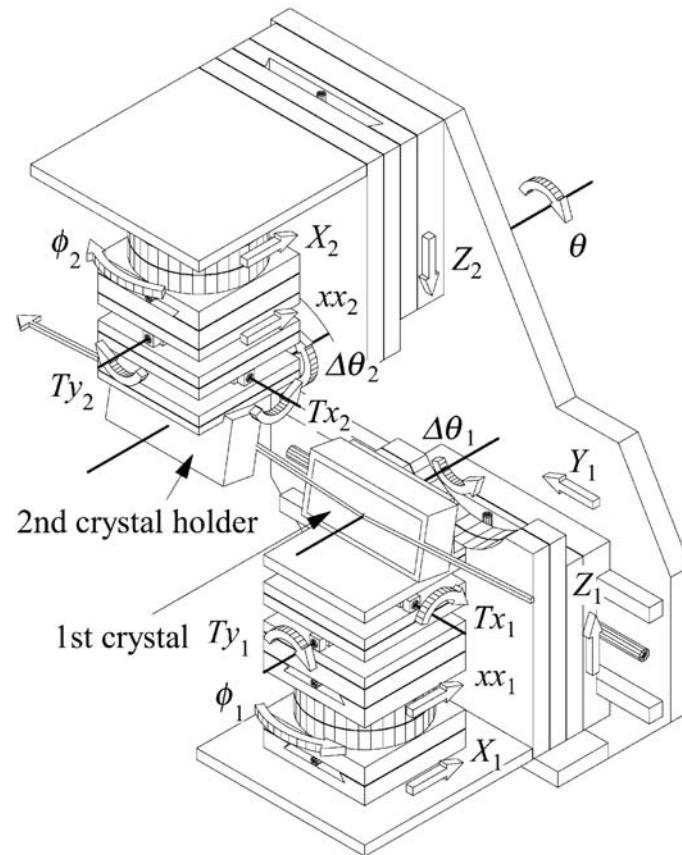
Two cams for two translation-stages
Rotation center at 2nd crystal

SPring-8 standard DCM



Offset $h = 30$ mm

$\theta_B = 3\text{--}27^\circ$ for higher energy range



High-precision adjustment stages
for undulator beamline DCM

Crystal cooling

Why crystal cooling ?

Q_{in} (Heat load by SR) = Q_{out} (Cooling + Radiation,...)

→ with temperature rise ΔT

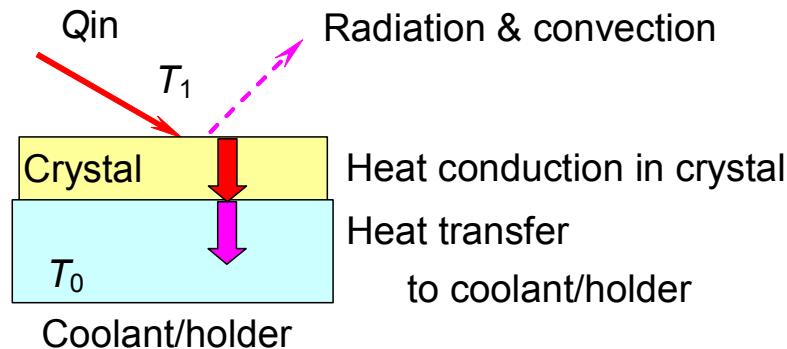
→ $\alpha \Delta T = \Delta d$ (d -spacing change)

α : thermal expansion coefficient

or → $\Delta \theta$ (bump of lattice due to heat load)

Miss-matching between 1st and 2nd crystals occurs:

- Thermal drift, Loss of intensity, Broadening of beam, loss of brightness
- Melting or limit of thermal strain → **Broken !**



Solution for crystal cooling

We must consider:

Thermal expansion of crystal: α ,

Thermal conductivity in crystal: κ ,

Heat transfer to coolant and crystal holder.

Solutions:

(S-1) $\kappa/\alpha \rightarrow$ Larger

(S-2) Large contact area between crystal and coolant/holder
→ larger

(S-3) Irradiation area → Larger, and power density → smaller

Figure of merit

	Silicon 300 K	Silicon 80 K	Diamond 300 K
κ (W/m/K)	150	1000	2000
α (1/K)	2.5×10^{-6}	-5×10^{-7}	1×10^{-6}
$\kappa / \alpha \times 10^6$	60	2000	2000

Figure of merit of cooling:
Good for silicon (80 k) and diamond (300 K)

For SPring-8 case

Bending magnet beamline

Power and density : ~100 W, ~1 W/mm² @40 m

Method:

- Direct cooling with fin crystal ← S-2

Undulator beamline

(Linear undulator, $N= 140$, $\lambda u= 32$ mm)

Power and density : ~500 W , ~500 W/mm² @40 m

Methods:

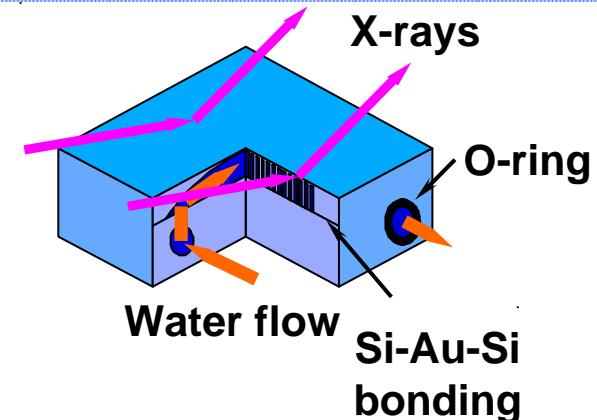
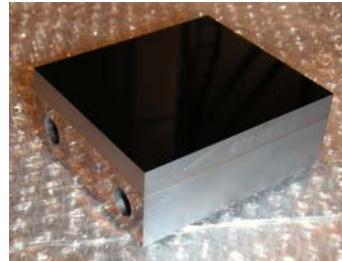
- Direct cooling of silicon pin-post crystal ← S-2
- + Rotated inclined geometry ($\rightarrow 10$ W/mm²) ← S-3
- or Cryogenic cooling using LN₂ circulation ← S-1
- or Indirect cooling of IIa diamond crystal ← S-1

Crystal monochromator at SPring-8

<Bending magnet beamline>

Power & power density:
 $\sim 100 \text{ W}$, $\sim 1 \text{ W/mm}^2$

Fin crystal direct-cooling - (S2)

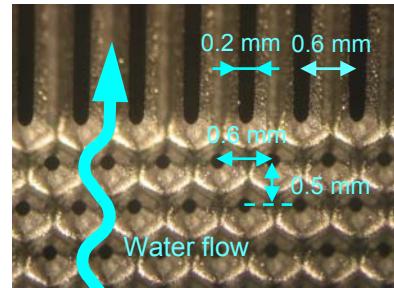
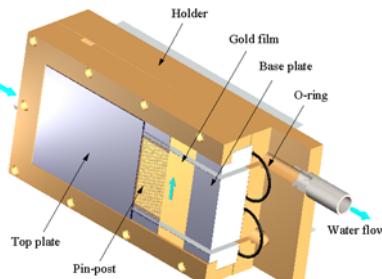


<Undulator beamline>

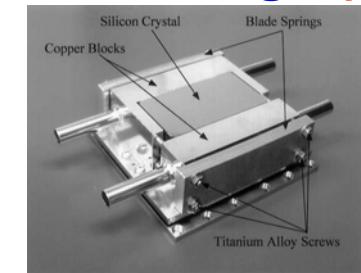
Linear undulator, $N= 140$, $\lambda u = 32 \text{ mm}$

Power & power density: $300\text{--}500 \text{ W}$,
 $300\text{--}500 \text{ W/mm}^2$

a) Direct cooling of silicon pin-post crystal – (S2) & (S3)



b) Silicon cryogenic cooling - (S1)



c) Ila diamond with indirect water cooling - (S1)



Mirror

- Higher harmonics rejection
- Bent mirror for focusing/collimation
- Figured mirror for micro~nanobeam

Mirror quality

Mirror quality must be considered.

→ Micro-roughness

- Reduction of reflectivity
- Lower-energy shift of critical energy
- Diffuse scattering

Optical (Zygo) range (<1 mm): ~ 0.3 nm rms or less

AFM range (<1 μm): ~ 1 nm rms or less

→ Insufficient coating

- Reduction of reflectivity
- Lower-energy shift of critical energy

Should be ~100%

→ Slope error

- Beam shape deformation
- Wave-front distortion
- Flux density loss

LTP range (<1 m): ~1 μrad or less

Mirror reflectivity

Mirror reflectivity for sigma-polarization:

$$R = \left| \frac{k_{iz} - k_{tz}}{k_{iz} + k_{tz}} \exp(-2k_{iz}k_{tz}\sigma^2) \right|^2$$

$$k_{iz} = \frac{2\pi}{\lambda} \cos \theta, \quad k_{tz} = \frac{2\pi}{\lambda} \sqrt{n^2 - \cos^2 \theta}$$

k_{iz}, k_{tz} : Normal components of incidence and transmitted wave vectors

n : complex index of refraction

θ : glancing angle

σ : high-spatial-frequency roughness (AFM region)

Surface roughness must be considered around critical energy (angle).

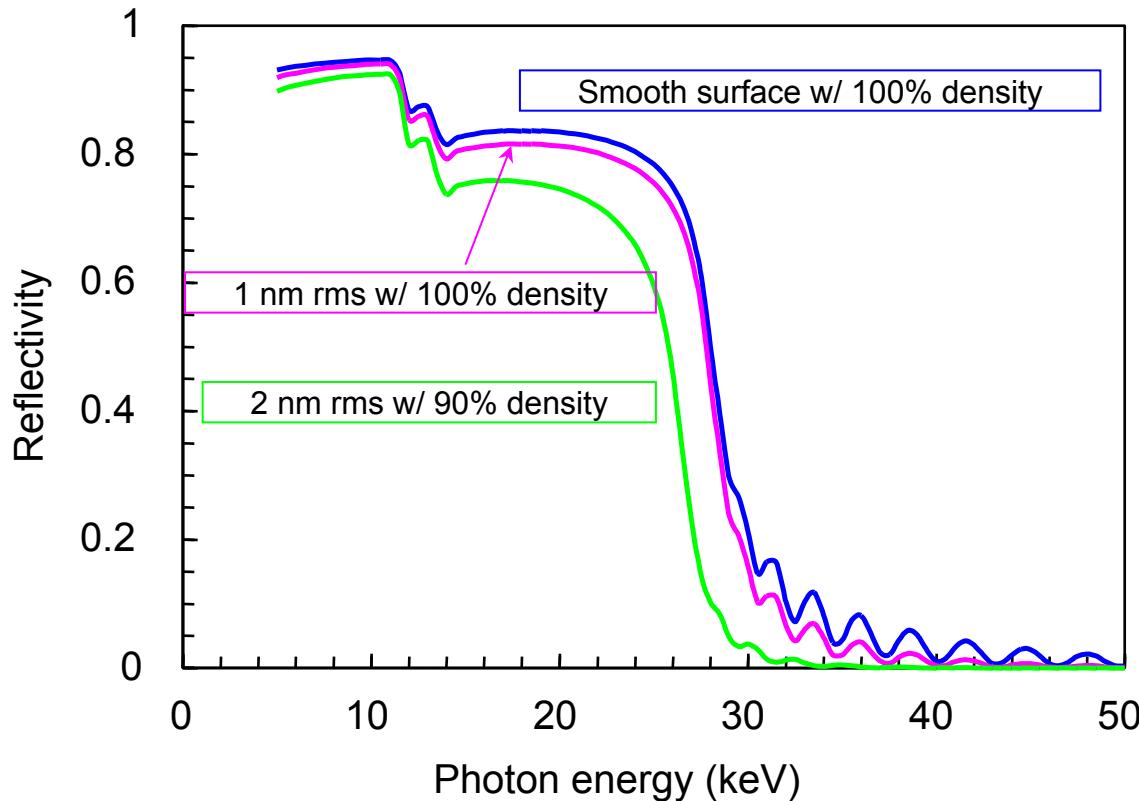
Effect of roughness

e.g. reflectivity of Pt mirror

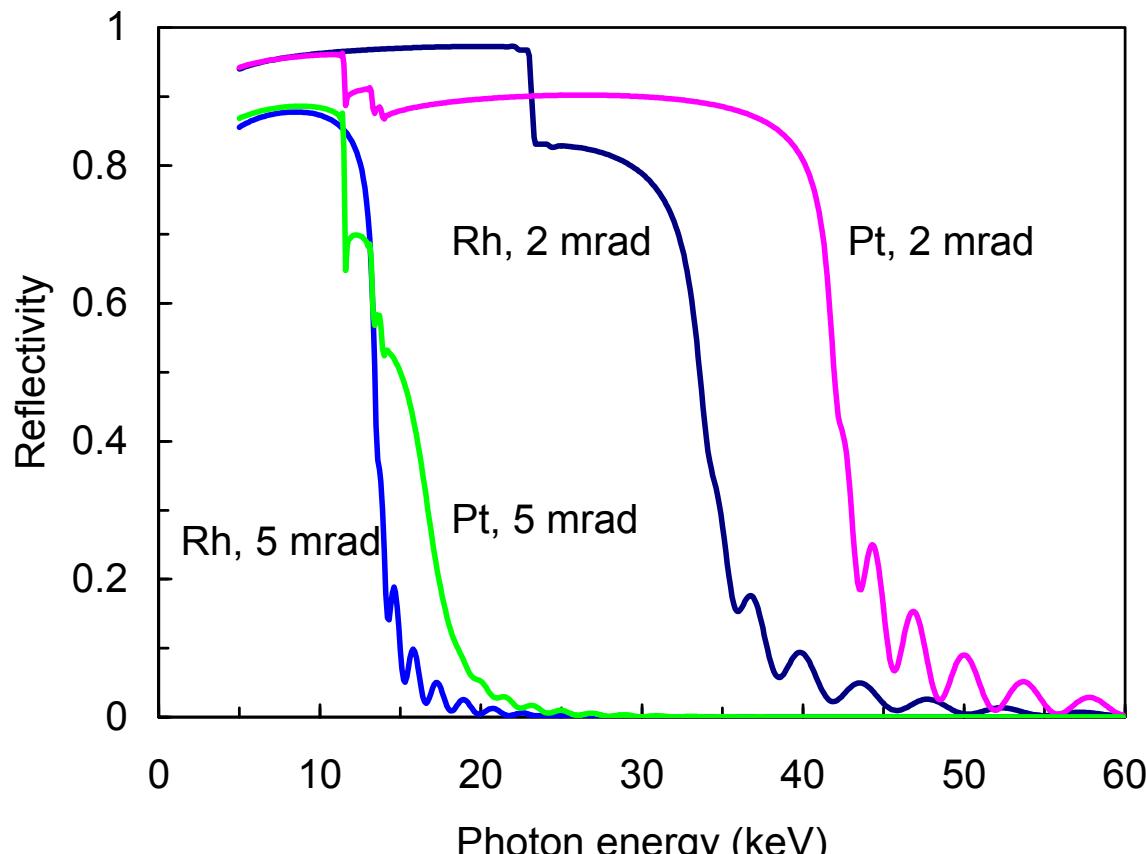
s-polarization

Glancing angle: 3 mrad

Film thickness: 50 nm



Example of mirror reflectivity



Thickness 50 nm, roughness 1 nm

Material, glancing angle, length

□ Material

Si, SiC for white radiation

SiO_2 , Glass,.. for monochromatic beam

□ Coating

Pt, Rh, Ni,...

Depending on energy, reflectivity, absorption edges,..

□ Glancing angle

2~10 mrad (For SPring-8 X-ray beamline)

Depending on energy, reflectivity, absorption edges,..

□ Mirror length

400 mm~1 m (For SPring-8 X-ray beamline)

Depending on the beam size and glancing angle

e.g. $100 \mu\text{rad} \times 50 \text{ m} / 5 \text{ mrad} = 1 \text{ m}$

Focusing with mirror

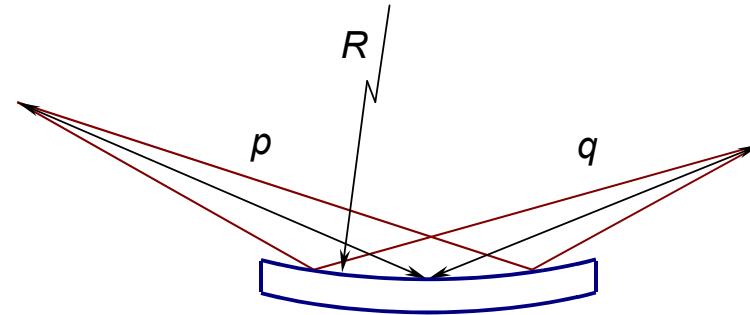
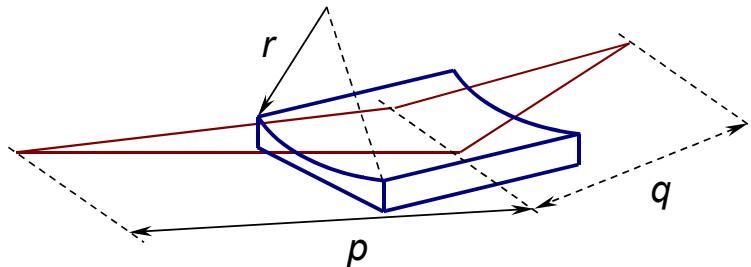
For beam focusing or collimation, we need;

elliptical mirror, ellipsoidal mirror, parabolic mirror, paraboloidal mirror,...

→ We can approximate by bending:

flat → meridional cylinder,

sagittal cylinder → toroidal,...



Sagittal focusing

w/ sagittal cylinder

$$r = \frac{2pq}{p+q} \sin \theta$$

Meridional focusing

w/ meridional cylinder

$$R = \frac{2pq}{(p+q) \sin \theta}$$

e.g.) $\theta = 5 \text{ mrad}$, $p = 40 \text{ m}$, $q = 10 \text{ m}$

$$r = 80 \text{ mm}, R = 3.2 \text{ km}$$

※ When $q \rightarrow \infty$

We obtain parallel beam:

$$r = 2p \sin \theta$$

$$R = 2p / \sin \theta$$

SPring-8 standard mirror support

For SPring-8 X-ray beamline

□ For undulator beamline

400-mm-long, vertical deflection, plane
700-mm-long, horizontal deflection, plane



For 400-mm-long mirror,
Vertical deflection, w/ bender

□ For bending magnet beamline

1-m-long, vertical deflection,
plane/cylindrical



Options

- Bender
- Indirect water-cooling (side cooling)

High heat-load 1st mirror for undulator beamline is installed with cryogenic cooling or water-cooling at some BL in SPring-8.

For 1-m-long mirror,
vertical deflection,
w/ bender, Indirect water-cooling

Focusing with mirror

Beam size using meridional cylinder mirror:

$$F_{\text{coma}} = 2.35 \Sigma M$$

$$F_{\text{spherical}} = \frac{3L^2 \theta (1 - M^2)}{16 p M}$$

$$F_{\text{Fabrication}} = 2 \times 2.35 \Delta_{\text{fabrication}} M p$$

$$F_{\text{total}} = \left[(F_{\text{coma}} + F_{\text{spherical}})^2 + F_{\text{Fabrication}}^2 \right]^{1/2}$$

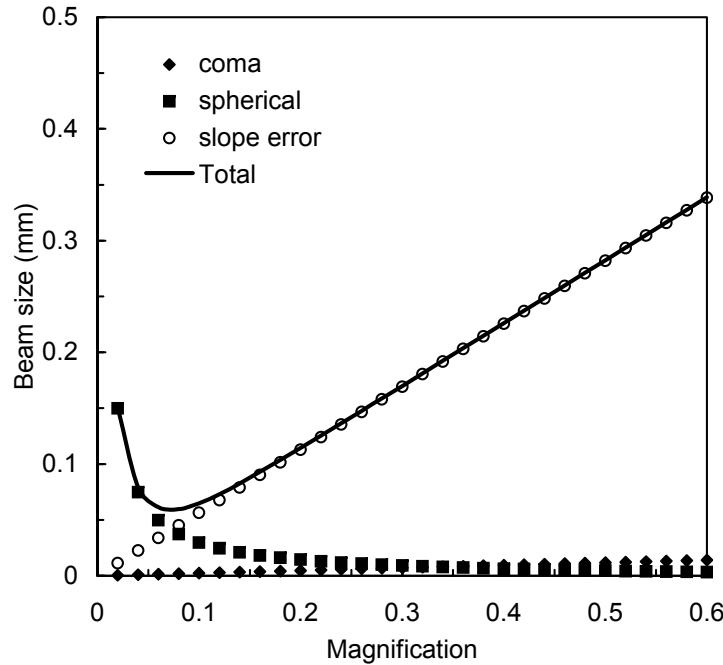
Σ : source size

M : magnification = q/p

L : mirror length

$\Delta_{\text{fabrication}}$: slope error

θ : glancing angle



e.g.

$\Sigma = 10 \mu\text{m}$

$L = 400 \text{ mm}$

$\Delta_{\text{fabrication}} = 3 \mu\text{rad}$

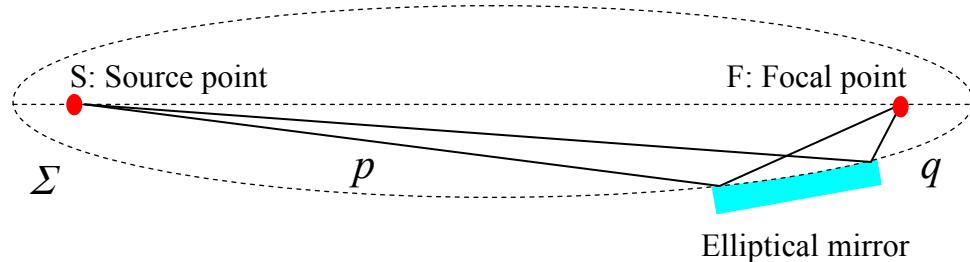
$\theta = 4 \text{ mrad}$

$p = 40 \text{ m}$

For micro~nonofocusing, we need precisely-polished and large NA elliptical K-B mirror near exp. station.

Diffraction-limited focusing

Focusing w/ figured mirror



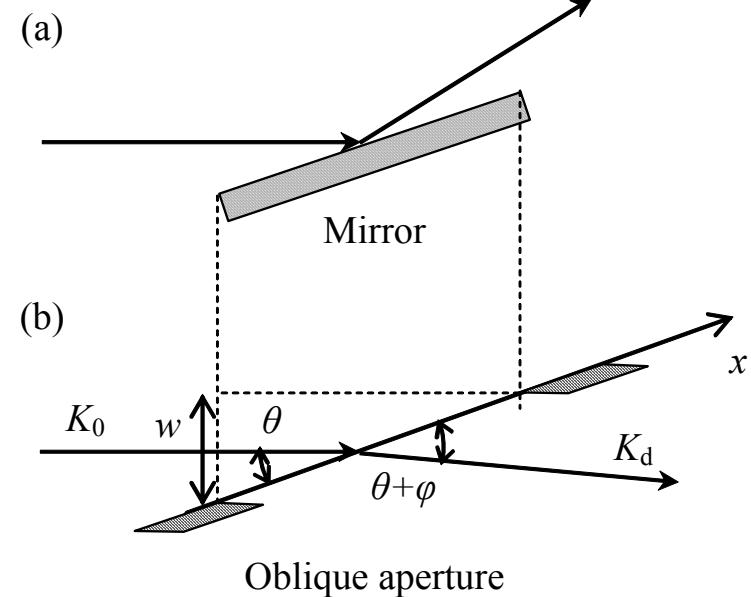
Estimation by oblique aperture model

→ Angular spread due to
Fraunhofer diffraction

$$FWHM_{\phi} = 2.7831 \frac{\lambda}{\pi w} \approx 0.8858 \frac{\lambda}{L \sin \theta}$$

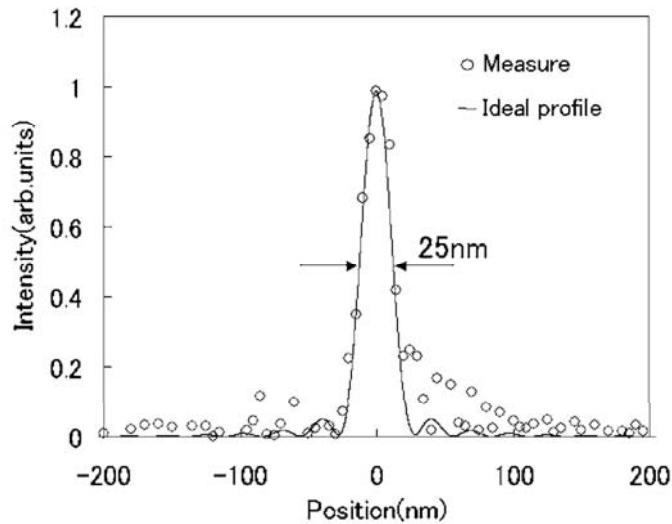
→ Spatial spread at q

$$FWHM_x = 0.8858 \frac{\lambda q}{L \sin \theta}$$

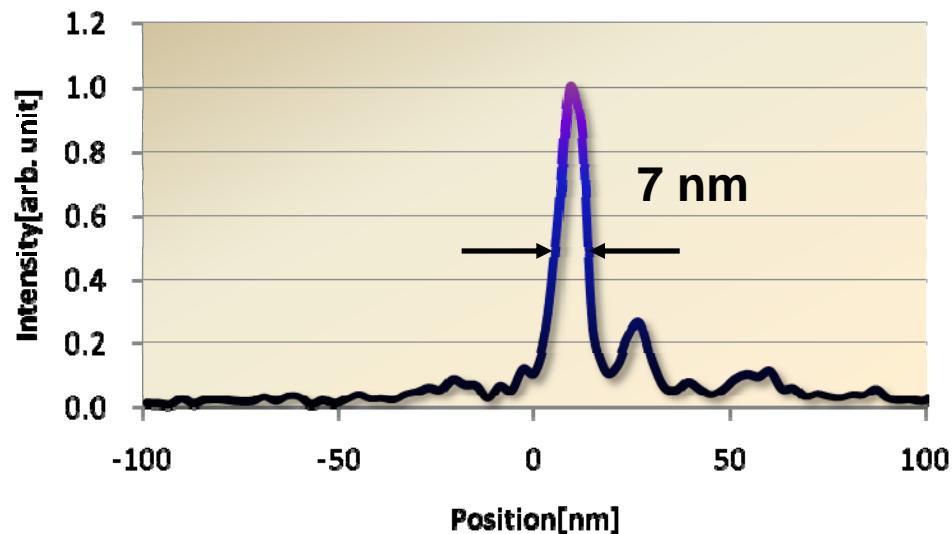


$$FWHM_x > \frac{q}{p} \Sigma \quad \leftarrow \text{diffraction-limited focusing}$$

Diffraction-limited focusing



H. Mimura et al.,
Appl. Phys. Lett. 90, 051903 (2007)



H. Mimura et al.,
Nature physics 6, 122-125 (2010)).

$$\theta_{ave} = 3 \text{ mrad}$$

$$\lambda = 0.083 \text{ nm } (E = 15 \text{ keV})$$

$$L = 45 \text{ mm}$$

$$q = 50 \text{ mm}$$

→ FWHM $\sim 27 \text{ nm}$

$$\theta_{ave} = 7 \text{ mrad}$$

$$\lambda = 0.062 \text{ nm } (E = 20 \text{ keV})$$

$$L = 80 \text{ mm}$$

$$q = 75 \text{ mm}$$

→ FWHM $\sim 7.3 \text{ nm}$

Polarization conversion

Phase retarder is used to convert the polarization for XMCD and other applications.

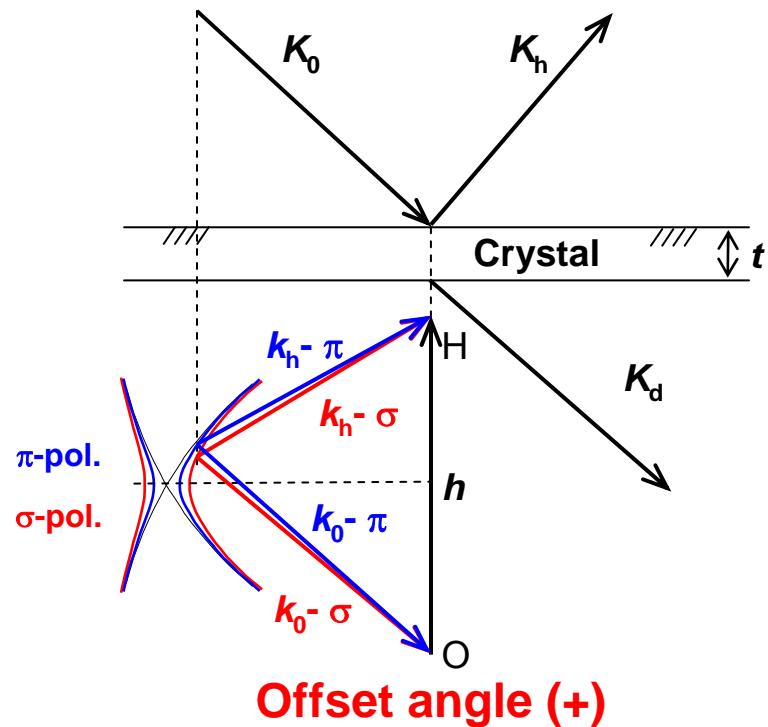
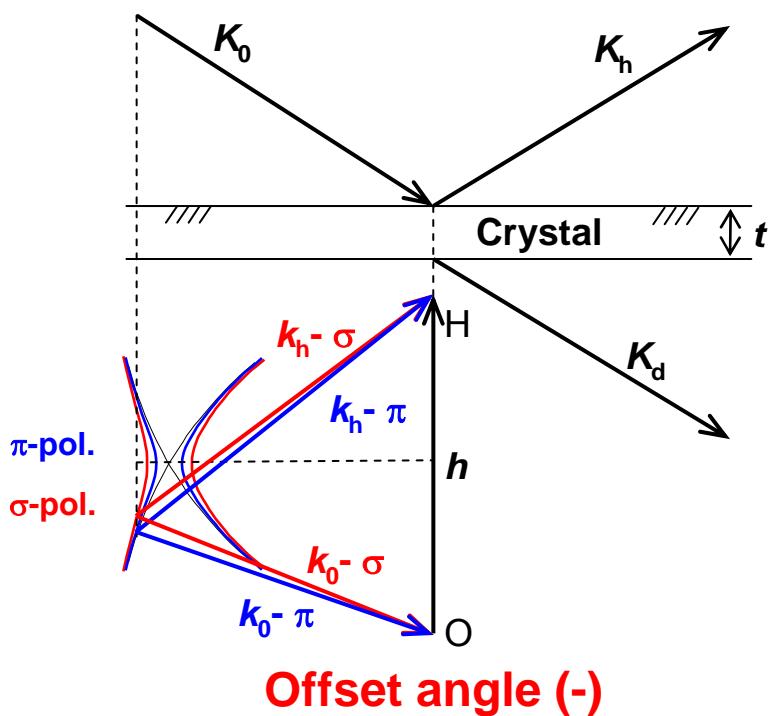
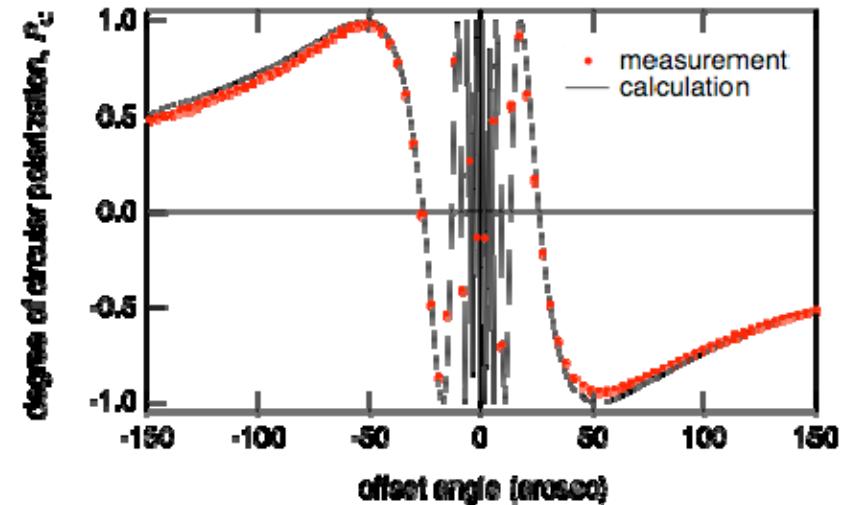
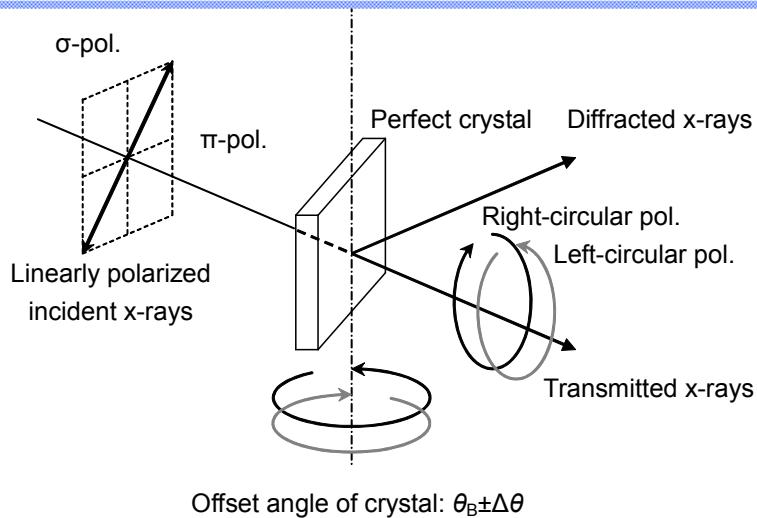
Horizontal polarization → right-/left-circular polarization

Horizontal polarization → vertical polarization

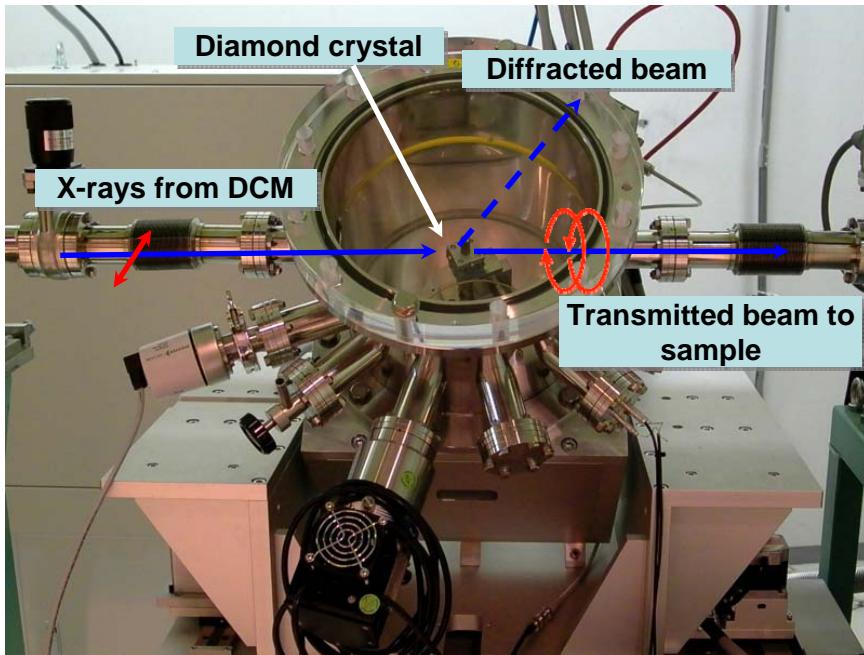
...

Crystal: IIa diamond,..

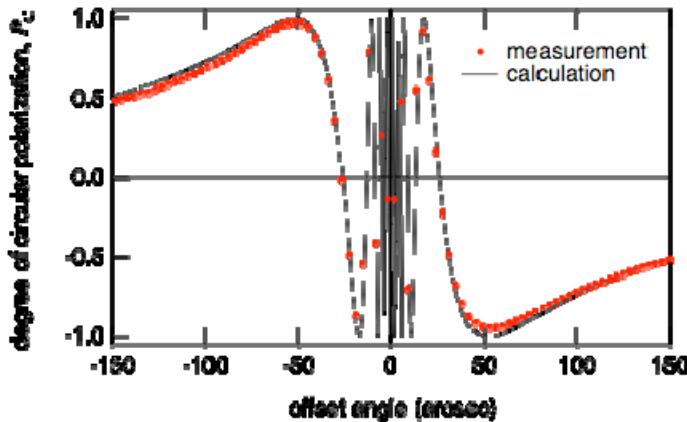
Polarization conversion



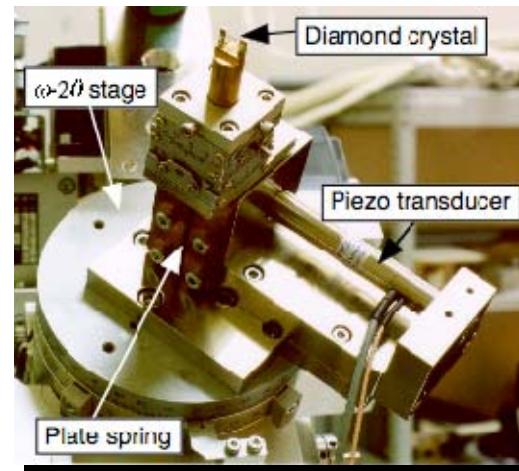
Diamond phase plate system BL39XU



Stages and vacuum chamber of phase retarder



0.45-mm-thick (111) diamond plate



Switcher of phase

Selection of phase plate

Thickness (mm)	Index	Reflection	Energy (keV)	Transmittance (%)
0.34	(111)	111 Bragg	5~5.8	3~7
		220 Laue	5.8~7.5	7~41
0.45	(111)	220 Laue	6~9	5~53
0.73	(111)	220 Laue	8~12	22~65
2.7	(001)	220 Laue	11~16	13~47

Spatial coherence

We need:

- small source size (σ_s) & long beamline (L)

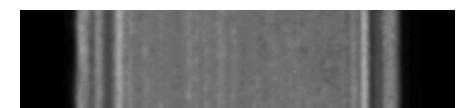
$$l_{coh} \propto \frac{\lambda L}{\sigma_s}$$

(depend on machine performance and facility design !)

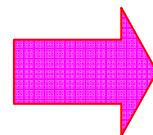
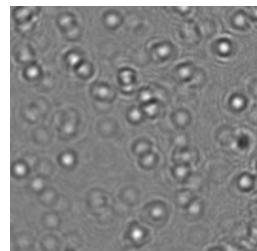
- w/ speckle-free optics.



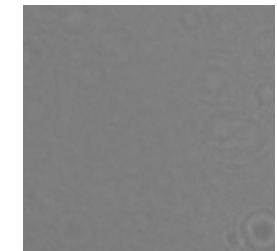
→ ultra smooth
surface



100 mm



→ void-free &
polished



300 µm

e.g. x-ray images using coherent x-rays

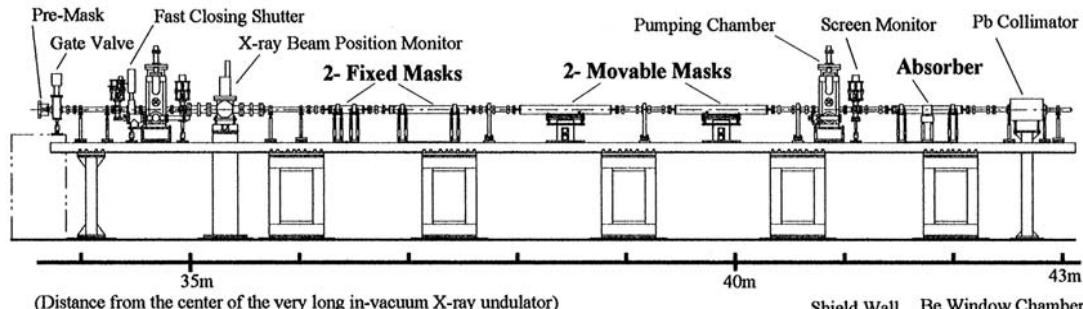
300 µm

47

Front-end

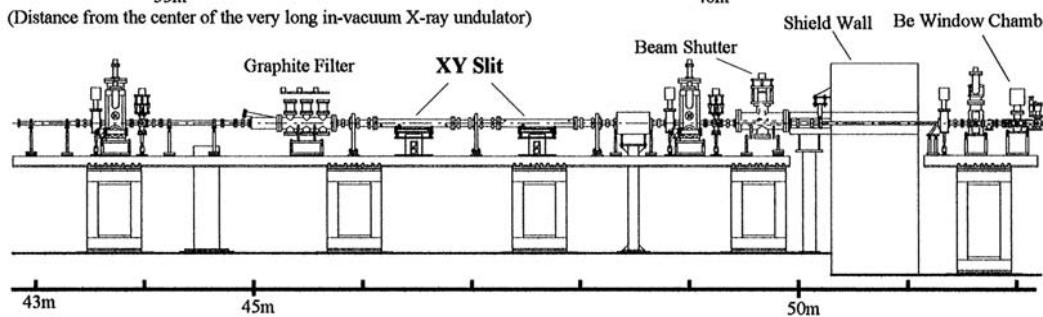
(1) Vacuum chamber (with ion pumps,...)

Pressure ($10^{-7} \sim 10^{-5}$ Pa)



(2) Main beam shutter (MBS)

- Water-cooled absorber
- Beam shutter



e.g. SPring-8 BL19LXU front-end

It reduces source power of **33 kW** down to **500 W**
for downstream optics

(3) Mask, XY-slit

Spatial power control

(4) Water-cooled Be windows

Protection of UHV

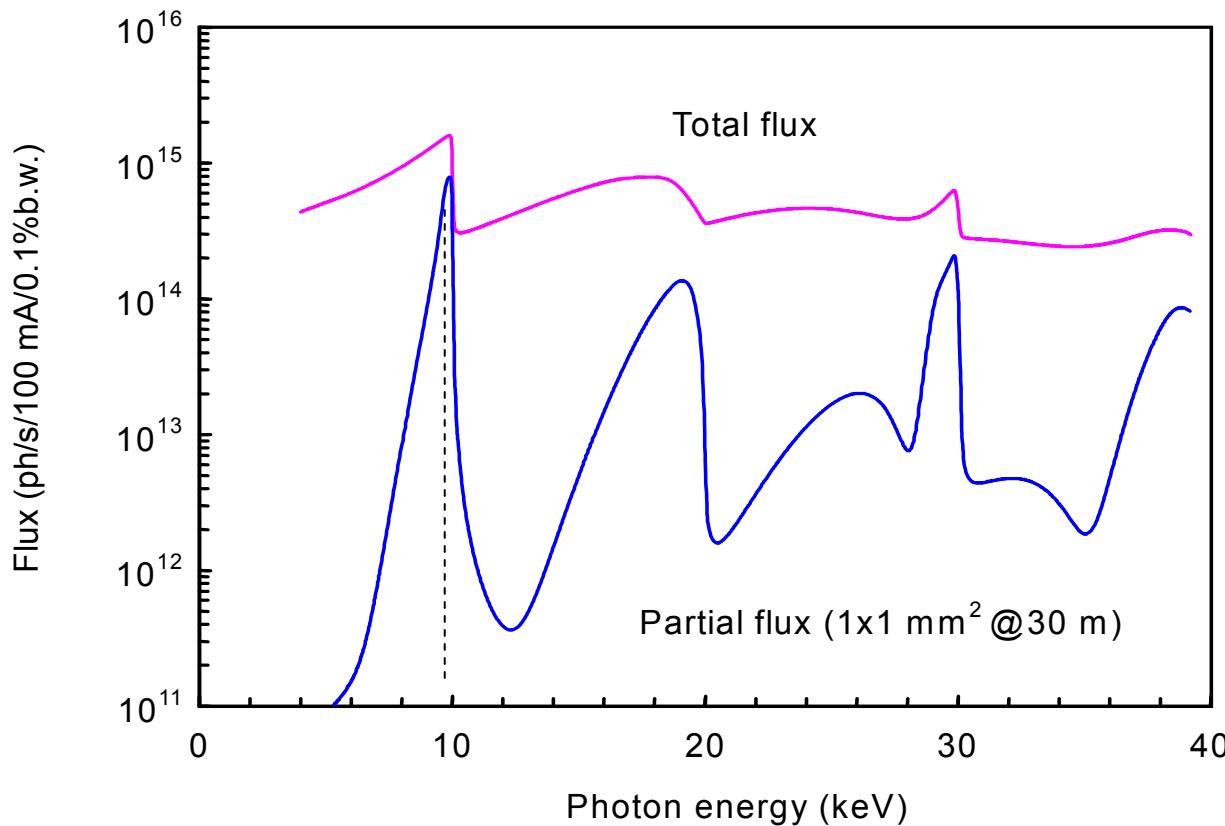
(5) Beam position monitor

New IXS beamline 43LXU

→ 50 kW to 1.5 kW

Grazing incidence technique w/ GlidCop
→ 10 kW/m

Reduction of power at front-end



e.g. Radiation From standard x-ray undulator $\lambda u=32$ mm, $N= 140$,
fundamental peak of 10 keV

Front-end eliminates the out-of-axis power spatially and reduce the power on the first optical element

Transport channel



e.g. BL14B2

□ Transport channel components

Exhaustion unit (ion-pump, TMP,...)

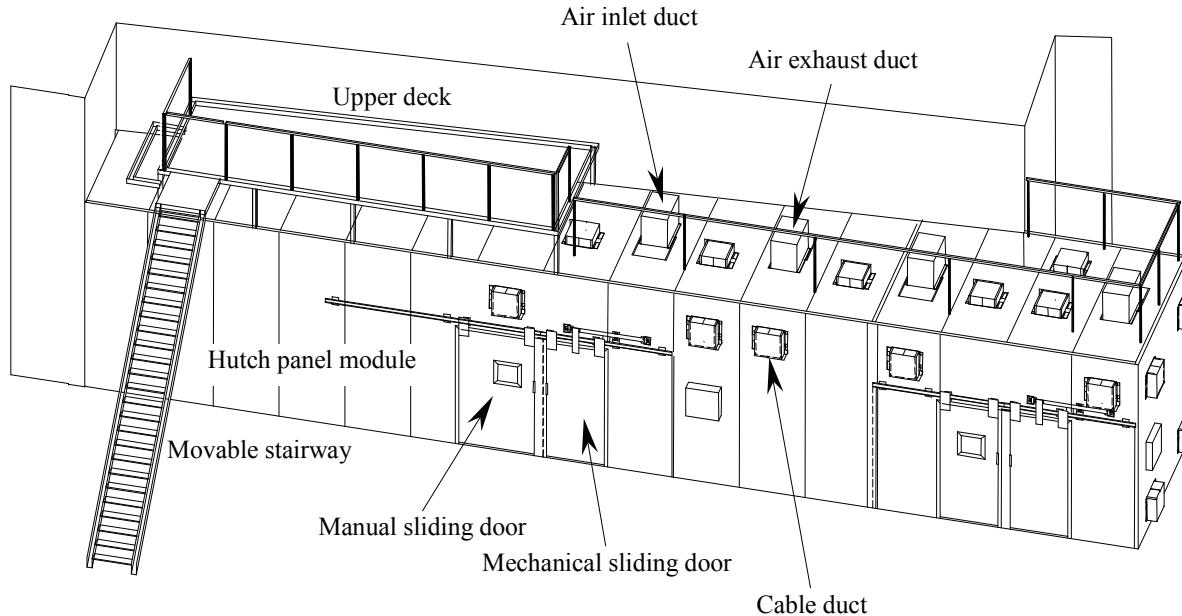
Down stream shutter (W or Pb)

Gamma stopper (Pb)

Beryllium window

Screen monitor

Shielding hutch @SPring-8



□Optics hutch

contains optics and transport channel components introducing white radiation

□Experimental hutch

contains experimental station equipments introducing monochromatic beam

- **Panel** Steel/ Lead/ steel sandwich structure
- **Lead thickness** Depends on the radiation condition (3~50 mm)
- **Module** Panel, Door, Cable duct, Air inlet/exhaust duct,...
- **Utility** Compressed air, Chilled water, electric power

Other issues on beamline design

- Boundary condition

- Storage ring and tunnel, neighboring beamline,..

- Radiation safety for shielding hutch, shutter,..

- Radiation shielding calculation (EGS4, STAC8,..)

- Control and interlock

- Common scheme in the facility.

- Connection with machine and safety control

- Others

- Utilities: electricity, water, compressed air, air conditioning.

- Environmental: vibration of floor, temperature of air,..

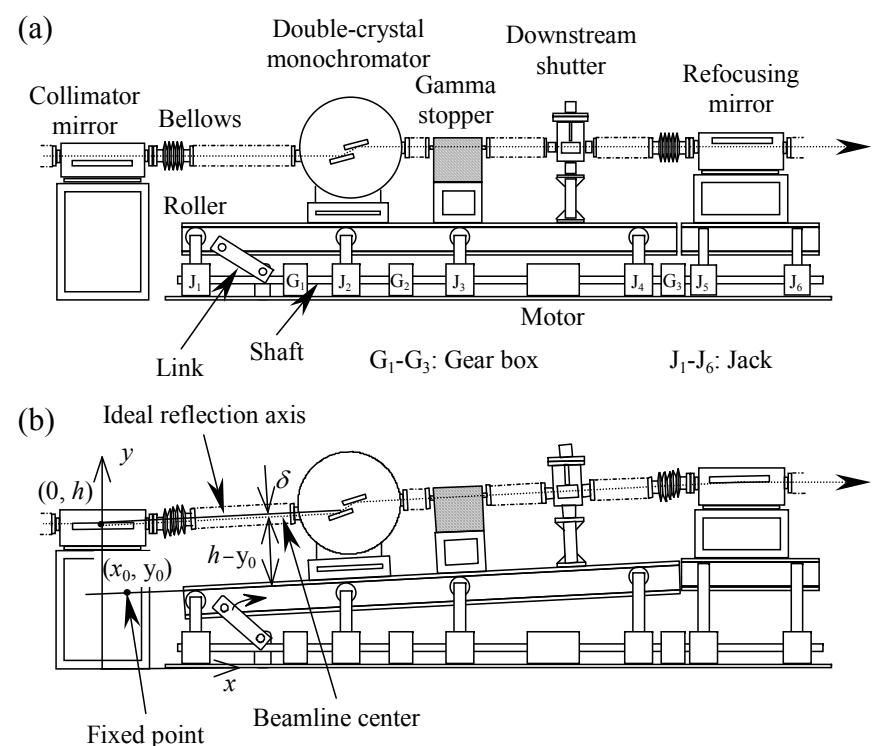
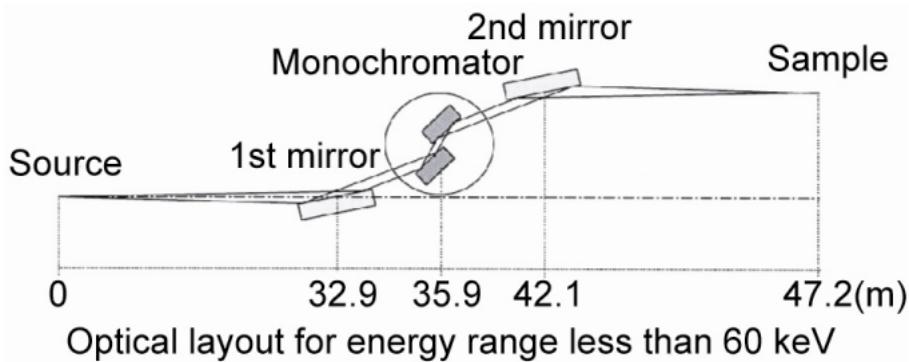
Cooperation with specialists in the facility is crucial !

Example of x-ray beamline

- SPring-8 case -

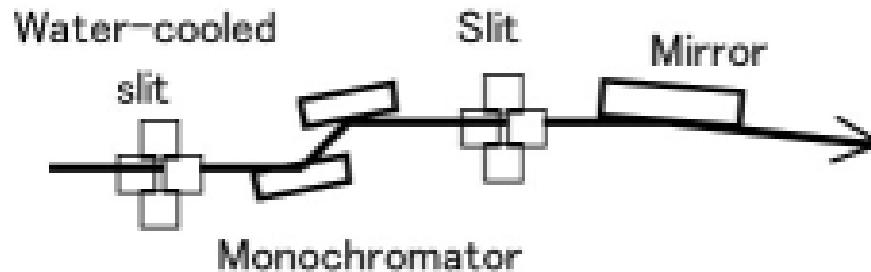
XAFS & single crystal diffraction

- Bending magnet
- Collimator mirror,
- + DCM,
- + refocusing mirror

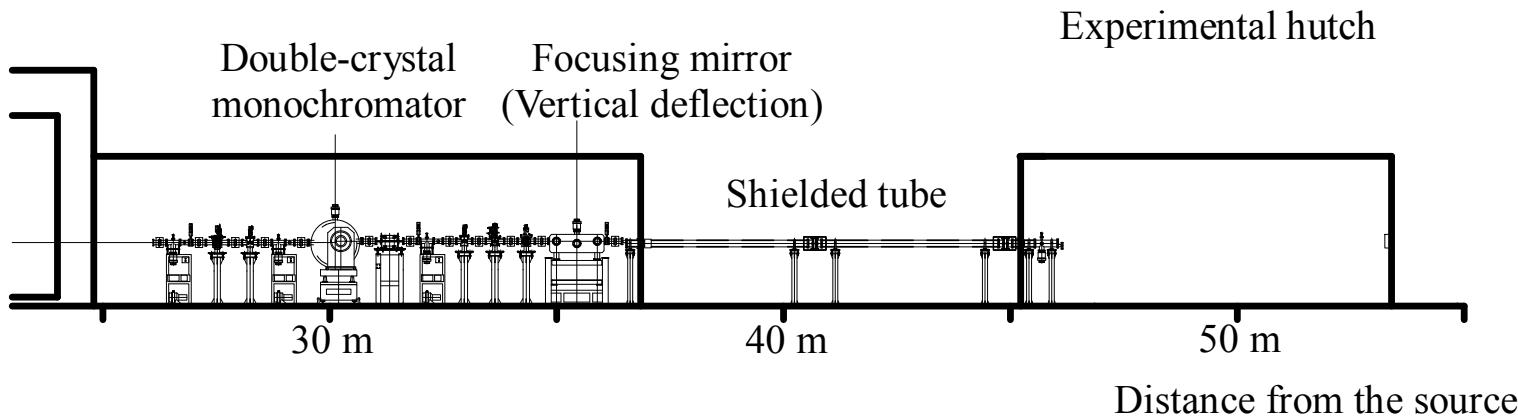


Protein crystallography

- Bending magnet
- DCM + focusing mirror

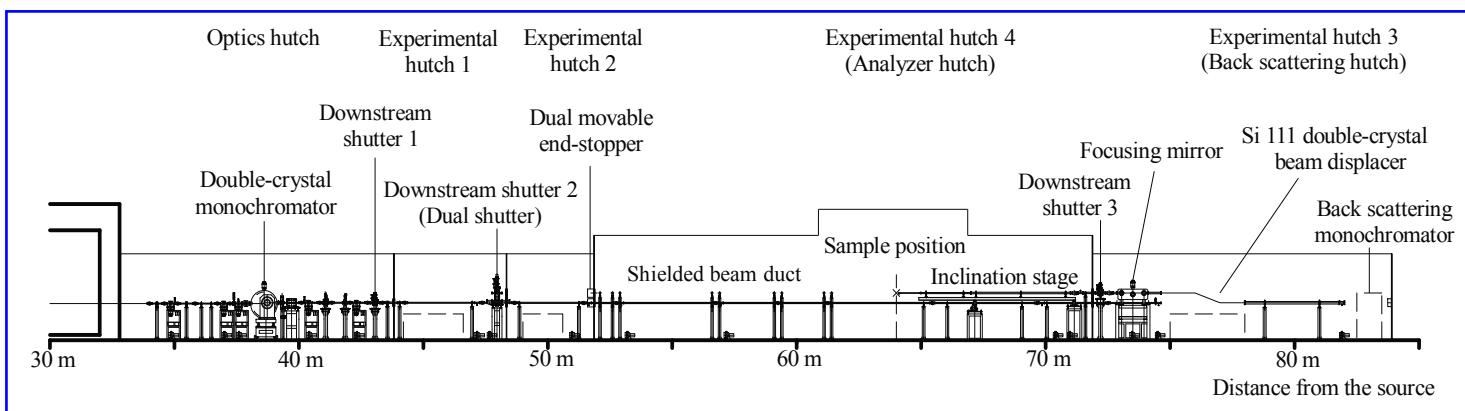
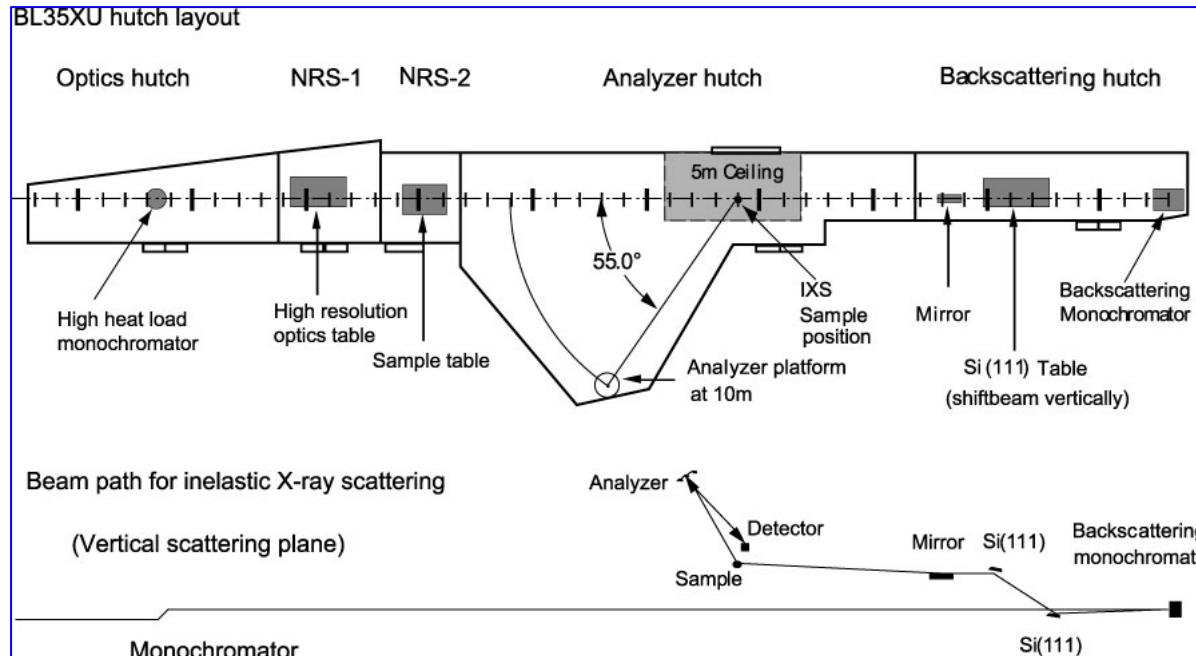


Optics hutch with standard components



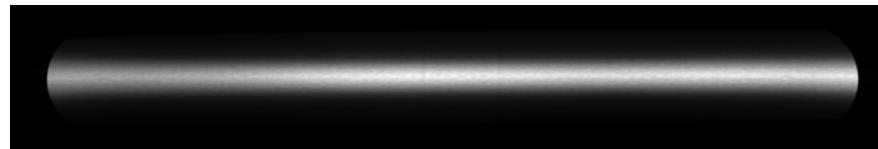
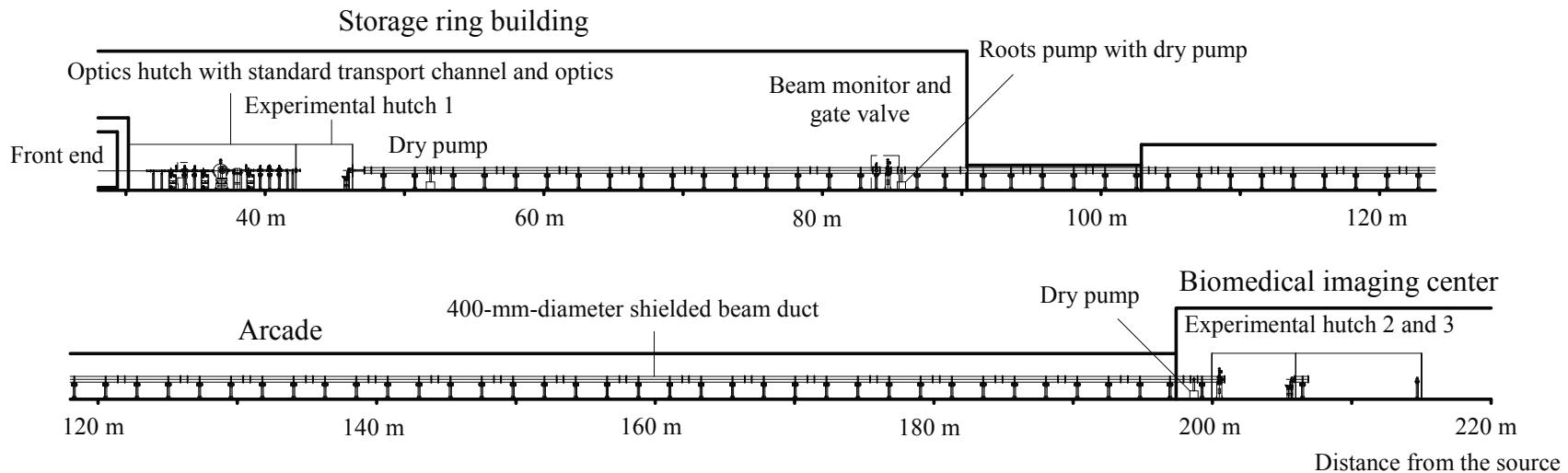
High resolution inelastic scattering

- Undulator
- DCM + back-reflection monochromator & analyzer (w/ \sim meV resolution)



200-m-long beamline

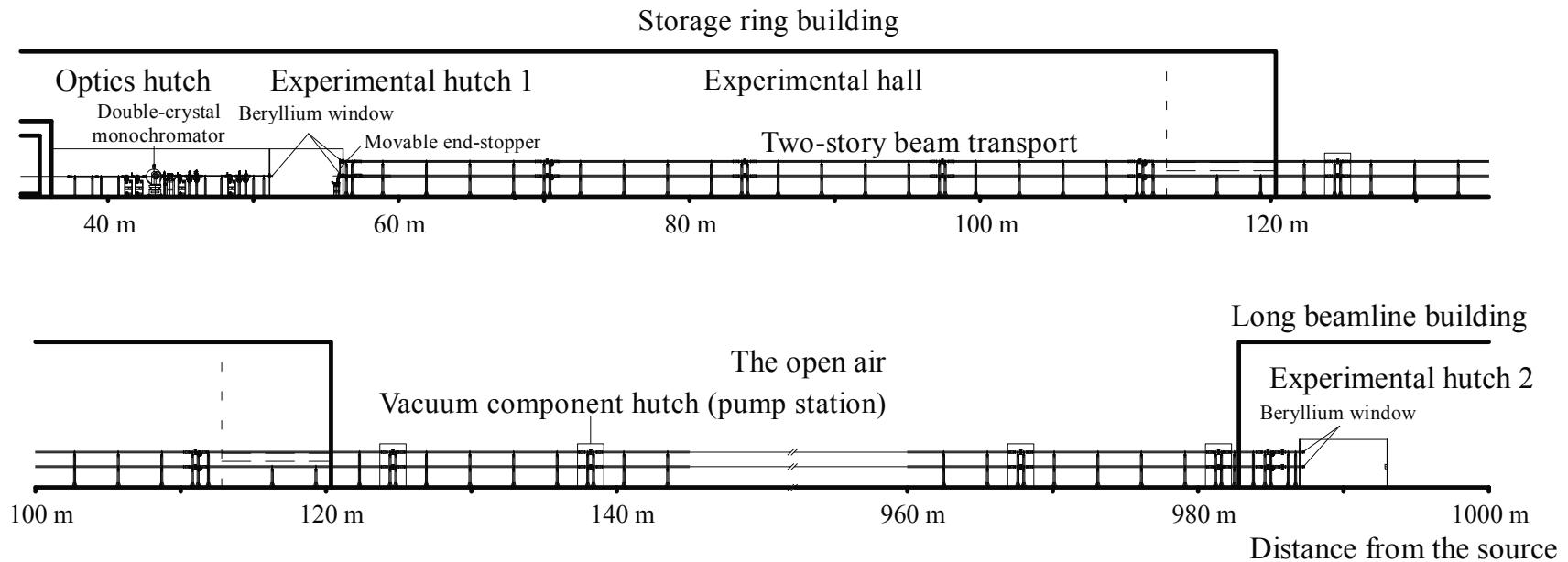
- Bending magnet
- DCM



300-mm-wide beam at end-station

1-km-long beamline

- Undulator
- DCM + tandem mirror



Wide and spatially-coherent X-rays at 1-km end station

Summary

- Starting point of X-ray beamline design is shown here,
w/ light source, monochromator, mirror, and other components.
- It helps to figure out what we can do at the beamline.
- We will have to go into details of design refinement using;
FEA (ANSYS), ray-tracing (SHADOW,...), shielding calculation,...
- Standardization of well-designed components helps beamline construction
and maintenance, saves the cost, man-power, and other resources.
- *Ray-tracing → wave simulation for “diffraction limited source and optics”*

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M. Suzuki, T. Uruga, T. Matsushita, T. Ohata,
Y. Furukawa, K. Yamauchi, and T. Ishikawa

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